Molecular chemistry approaches for tuning the properties of two-dimensional transition metal dichalcogenides

Simone Bertolazzi, Marco Gobbi, Yuda Zhao, Claudia Backes & Paolo Samorì

a Université de Strasbourg, CNRS, ISIS, 8 allée Gaspard Monge, 67000 Strasbourg, France
b Chair of Applied Physical Chemistry, Ruprecht-Karls University Heidelberg, 69120 Heidelberg, Germany
‡ Present address: Centro de Física de Materiales (CSIC-UPV/EHU), Paseo Manuel de Lardizabal, 5 – E-20018 Donostia – San Sebastián (Gipuzkoa) – Spain

*Correspondence should be addressed to: samori@unist.fr, bertolazzi@unistra.fr

Abstract

Two-dimensional (2D) semiconductors, such as ultrathin layers of transition metal dichalcogenides (TMDs), offer a unique combination of electronic, optical and mechanical properties, with potential to enable a host of new device applications spanning from flexible/wearable (opto)electronics to energy-harvesting and sensing technologies. A critical requirement for developing practical and reliable electronic devices based on semiconducting TMDs is achieving a full control over their charge-carrier polarity and doping. Inconveniently, such a challenging task cannot be accomplished by means of well-established techniques (e.g. ion implantation), which unavoidably damage the 2D crystals resulting in degraded device performances. Nowadays, a number of alternatives are being investigated, including various (supra)molecular chemistry approaches relying on the combination of 2D semiconductors with electroactive donor/acceptor molecules. As yet, a large variety of molecular systems have been utilized for functionalizing 2D TMDs via both covalent and non-covalent interactions. Such research endeavours enabled not only the tuning of the charge-carrier doping but also the engineering of the optical, electronic, magnetic, thermal and sensing properties of semiconducting TMDs for specific device applications. Here, we will review the most enlightening recent advancements in (supra)molecular chemistry
methods for tailoring the properties of atomically-thin TMDs — in the form of substrate-supported or solution-dispersed nanosheets — and we will discuss the opportunities and the challenges towards the realization of novel hybrid materials and devices based on 2D semiconductors and molecular systems.

1. Introduction

Two-dimensional (2D) materials represent an ever-growing research area that encompasses multiple disciplines and spans from fundamental science to novel device applications. Such a terrific endeavour essentially took off in 2004 with the isolation of graphene from graphite via micromechanical cleavage, also known as scotch tape method. This simple-yet-effective technique was soon after utilized for the preparation of atomically-thin sheets of various layered van der Waals materials, including molybdenum disulfide (MoS\(_2\)) and other transition metal dichalcogenides (TMDs). Unlike graphene that is a semimetal and does not possess a bandgap in its pristine form — a property that is essential for application in digital electronics —, the family of layered-TMD materials offers a broad variety of electronic and optical properties, including semiconducting bandgaps in the visible range of the electromagnetic spectrum. Bulk TMD crystals were investigated back in the 1960s and TMD nanosheets with thickness < 100 Å were reported in 1966 by Frindt, who was pioneering the exfoliation of MoS\(_2\) by adhesive-tape peeling at that time. Noticeably, in 1986 — that is almost two decades before the advent of graphene and 2D crystals — Joensen, Frindt and Morrison succeeded in preparing single-layer thick sheets of MoS\(_2\) via ion-intercalation methods. Nowadays, ultrathin TMDs are among the most popular 2D materials beyond graphene, with monolayer MoS\(_2\) being their prototypical and most investigated element. After the demonstration, in 2011, of dual-gated single-layer MoS\(_2\) transistors (ref. 20) with excellent \(I_{on}/I_{off}\) switching ratio (~10\(^8\)) and promising field-effect
mobility (up to \( \sim 60 \text{ cm}^2\text{V}^{-1}\text{s}^{-1} \)),\textsuperscript{21, 22} tremendous research efforts have been devoted to exploring the use of 2D-TMD semiconductors — e.g. MoS\(_2\), WS\(_2\), MoSe\(_2\) and WSe\(_2\) — as active layers in electronic switches, such as field-effect transistors (FETs).\textsuperscript{23-26} Thanks to their atomic-scale thicknesses and sizable energy bandgaps (1-3 eV),\textsuperscript{27} these materials offer ideal electrostatic control in the FET geometry,\textsuperscript{28, 29} and for this reason they have been proposed as potential alternatives to silicon for next-generation \textit{More-than-Moore} technologies.\textsuperscript{30, 31} The transition from indirect to direct bandgap that occurs when the thickness of the TMDs is scaled down to a single layer,\textsuperscript{32-34} has also attracted great attention in view of potential applications in optoelectronic devices,\textsuperscript{26, 35-37} in particular photodetectors\textsuperscript{38-40} and solar cells.\textsuperscript{41-44} Besides having excellent optical and electronic properties, ultrathin TMDs are also characterized by a high degree of mechanical flexibility, robustness and light weight,\textsuperscript{45, 46} which makes them ideal candidates for the fabrication of flexible, foldable and wearable/portable (opto)electronic devices.\textsuperscript{23, 47-49}

Though impressive advances have been made in this direction,\textsuperscript{17, 18} numerous challenges still need to be tackled towards practical and reliable technologies based on 2D semiconductors.\textsuperscript{1, 3, 23} In particular (i) the synthesis of large-area and high-quality films of monolayer TMDs with low densities of defects and impurities,\textsuperscript{16, 50} as well as (ii) the development of sound strategies to control the charge-carrier type and the doping level in 2D semiconducting crystals remain major challenges to be faced.\textsuperscript{1, 51-53} Whereas a lot of progress has been reported and reviewed on the synthesis of 2D-TMD sheets,\textsuperscript{16, 50, 54-56} seemingly, relatively less work has been focused on the second critical aspect, which is nevertheless a veritable bottleneck to the incorporation of 2D TMDs in (opto)electronic technologies.\textsuperscript{1, 51-53} Achieving a systematic control over charge-carrier doping is essential for minimizing detrimental Schottky barriers at metal-semiconductor interfaces,\textsuperscript{57} as well as for manufacturing \textit{p-n} junctions and transistors with reproducible electrical characteristics, which are crucial requirements for the production of
complementary-logic devices and circuits. Conventional doping techniques, such as ion implantation and dopant diffusion, are extremely challenging to be implemented in combination with 2D TMDs, since damages/defects induced by such processes in ultrathin crystals can have drastic effects on their structural and electrical properties. Various alternatives have been proposed — comprehensively reviewed in refs 51, 53 — such as alloying, transition-metal substitution/inciporation, plasma-assisted doping, chalcogen substitution via defect engineering, as well as charge transfer via interaction with molecular adlayers. In particular, the use of molecular systems interfacing 2D semiconducting sheets is emerging as a promising, versatile and viable route for controlling the charge-carrier doping and polarity of ultrathin TMDs. Being essentially all surface, atomically-thin crystals are extremely sensitive to all influences of a surrounding environment, and their properties can thereof be easily modified by external variables. For instance, FETs based on monolayer TMDs sheets were reported to be highly sensitive to a large number of gas molecules, which interact with the surface of the 2D semiconducting channel modulating its charge-carrier density via electrical dipoles or charge-transfer interactions. Hence, one can take advantage of the exquisite sensitivity of ultrathin TMDs to tune their electronic and optical properties by controlling the physico-chemical variables of the surrounding environment, for instance by engineering ad hoc (supra)molecular systems interfacing the 2D sheets. Indeed, a variety of molecular chemistry approaches (see Fig. 1), based on covalent and non-covalent interactions between molecules and defective/pristine TMDs, have been reported in the last few years. Such studies enabled not only the tuning of the charge-carrier doping but also the tailoring of other functional properties critical for (opto)electronic applications, such as for instance charge transport, charge injection, optical
emission and adsorption,\textsuperscript{96-103} as well as dispersibility in liquid media (inks),\textsuperscript{104-106} the latter being crucial for the processing of large-area films and devices.\textsuperscript{107, 108}

In this review article, we will describe and discuss the molecular chemistry strategies that have been pursued so far to functionalize 2D TMDs — in particular the so-called MoWSeS materials (\textit{i.e.} MoS\textsubscript{2}, WS\textsubscript{2}, MoSe\textsubscript{2} and WSe\textsubscript{2})\textsuperscript{2} — and to control their charge-carrier doping along with other materials’ characteristics. It is worth noting that such strategies have been implemented both on substrate-supported 2D layers (Sections 2-4) and on dispersions of TMD nanosheets in solution (Section 5). More specifically, Section 2 will be focused on non-covalent methods to decorate the top and bottom surfaces of 2D TMDs with electroactive (\textit{i.e.} donor and acceptor) molecules, which can be eventually deposited in the form of highly-ordered molecular layers.\textsuperscript{83} Afterwards, we will show how chemical methods can be employed to control and optimize optical processes in 2D semiconductors, \textit{e.g.} the photoluminescence emission in direct-bandgap monolayer TMDs (Section 3). Recently, various defect- and phase-engineering approaches have been developed for functionalizing ultrathin TMDs \textit{via} covalent binding of molecular species onto their basal-plane surface.\textsuperscript{80, 109} These techniques will be presented in Section 4. Research endeavours have also been devoted to the development of liquid-phase methods for tailoring the properties of semiconducting nanosheets dispersed in aqueous or organic solutions with a number of molecules and (bio) polymers.\textsuperscript{110-112} The availability of inks of functionalized TMDs is expected to open up novel possibilities for the processing of large-area hybrid materials and devices — \textit{e.g.} by making use of ink-jet printing methods\textsuperscript{106} — based on combinations of 2D semiconductors and molecular systems (Section 5). Due to their broader commercial availability and well-established exfoliation processes, MoWSeS materials are the most investigated among the TMDs,\textsuperscript{9} and only a few experimental and theoretical works exist on the effects of functional
molecules on the (opto)electronic properties of other TMD materials (e.g. group-10 PdSe$_2$ and group-5 NbSe$_2$), which have been grouped and reviewed all together in Section 6. Molecular-design strategies can be used to “bridge” a virtually-infinite number of molecules to 2D crystals (Section 1.2), providing unique opportunities not only to modulate the properties of ultrathin TMDs — on demand for device applications — but also to introduce new functionalities with the aim of developing novel multifunctional/multiresponsive materials and devices. These opportunities and the associated challenges will be discussed in the last part of this review (Section 7).

### 1.1 Materials and properties

Single sheets of TMDs, commonly indicated with the formula MX$_2$, consist of an atomic layer of transition metals (M = Mo, W, Ti, Nb, Ta, Re, Pt, Pd etc.) sandwiched between two atomic layers of chalcogens (X = S, Se and Te).\(^{11,115}\) More than 40 bulk MoX$_2$ crystals — resulting from different permutations of M and X elements — are available in nature, and most of them possess a layered structure.\(^{1,2,115}\) In such layered materials, the atoms within individual sheets are connected via strong covalent bonds (1-10 eV/atom), whereas adjacent sheets interact with each other through weak van-der-Waals forces (10s of meV/atom).\(^{1,2,115}\) For this reason, similarly to graphite and other layered materials,\(^{116}\) TMDs can be easily exfoliated into single- and few-layer thick nanosheets by making use of various techniques, including micromechanical cleavage via scotch-tape peeling,\(^{5,13}\) as well as liquid-phase methods based on intercalation of ions (chemical exfoliation),\(^{117-121}\) ultrasonication/shear exfoliation in organic solvents\(^{122,123}\) or aqueous surfactant solutions.\(^{105}\) Nowadays, graphene is not the only 2D material to be available in the form of high-quality large-area films produced via chemical vapour deposition (CVD).\(^{124,125}\) In fact, ultrathin films of MoWSe$_2$ materials\(^{50,54,126-128}\) and other TMDs (e.g. ReS$_2$\(^ {129}\) and SnSe$_2$\(^ {130}\)) can also be grown by CVD methods on technologically-relevant substrates (e.g. oxidized Si wafers), and lateral heterostructure of
different 2D semiconductors — promising for next-generation (opto)electronic devices — have already been reported in the literature.\textsuperscript{131,132}

Nowadays, ultrathin TMDs are intensively investigated for applications in electronic switches, \textit{p-n} junctions, logic gates and optoelectronic devices.\textsuperscript{23,27,35} In fact, several high-quality semiconducting TMDs are currently available with various electronic properties, as well with different charge-transport polarity. For instance, ultrathin MoS\textsubscript{2} behaves as a unipolar \textit{n}-type semiconductor, whereas 2D WSe\textsubscript{2} commonly displays ambipolarity.\textsuperscript{27}

**Crystal Structures.** TMDs can have multiple crystal structures, depending on the mutual coordination of the M and X elements,\textsuperscript{115,133} and transitions between different phases have been predicted\textsuperscript{134} and triggered experimentally \textit{via} multiple physico-chemical stimuli.\textsuperscript{135} The most common polytypes (see Fig. 2) are the hexagonal — indicated as 1H for single layers and 2H for multilayers — with trigonal prismatic (D\textsubscript{3h}) coordination, and the tetragonal 1T with octahedral coordination (O\textsubscript{h}).\textsuperscript{115,133} The 1T polytype often undergoes a lattice distortion into a 1T\textsuperscript{'} form, as for instance in the case of MoTe\textsubscript{2}.\textsuperscript{136,137} For monolayer MoWSe\textsubscript{2}, the most stable polytype is 1H, which is associated with semiconducting properties and direct bandgaps.\textsuperscript{8,138,139} However, metastable 1T/1T\textsuperscript{'} polytypes with metallic characteristics can be prepared with various methodologies.\textsuperscript{135} In 1991, Sandoval \textit{et al}.,\textsuperscript{140} demonstrated that monolayer MoS\textsubscript{2} sheets produced \textit{via} lithium-ion intercalation have octahedral phase, and they also proposed a possible 1T\textsuperscript{'} distorted configuration. Such results were confirmed by a number of subsequent works (\textit{e.g.} refs 121, 141-143) along with possible strategies for prompting transitions between the metallic 1T/1T\textsuperscript{'} and the semiconducting 1H phases. In 2011, Eda \textit{et al}.,\textsuperscript{142} reported on photoluminescence emission — typical of 1H semiconductors — from MoS\textsubscript{2} nanosheets produced \textit{via} lithium-ion intercalation. The key to this achievement was the 1T/1T\textsuperscript{'}\textrightarrow;1H conversion triggered by thermal annealing ($T \geq 300$ °C) after deposition on a substrate.\textsuperscript{142} This work stimulated the investigation of phase-engineering techniques for
modulating the properties of ultrathin TMDs, which can be conveniently utilized in combination with molecular chemistry approaches, as discussed in Section 4. The properties and the stability of different polytypes in TMDs “beyond MoWSeS” can vary significantly, depending on the \(d\)-electron number of the transition metal (see Section 6). For example, monolayer PtSe\(_2\) (group 10) is a 2D semiconductor with indirect bandgap of \(\sim 1.2\) eV (theory) and 1T stable polytype; NbSe\(_2\) nanosheets (group 4) have stable 1H/2H metallic phase and were shown to maintain superconducting characteristics down to the monolayer thickness; single-layer MoTe\(_2\) (group 6) displays a 1T′ semimetallic polytype that is almost as stable as its 1H counterpart, whereas ultrathin ReS\(_2\) (group 7) presents a distorted semiconducting 1T′ structure with diamond-shape lines that are responsible for strongly anisotropic transport properties. Here, we will not enter into the details of such a wealth of structures and properties, which have been thoroughly presented elsewhere (e.g. refs 9, 27, 115, 150). However, we point out that the physico-chemical properties of ultrathin TMDs, as well as their interactions with their surroundings, can vary dramatically with the 2D-material structural phase, and such variability cannot be overlooked when dealing with molecular chemistry methods for the functionalization of ultrathin TMDs.

**Defects.** Another important aspect to consider is the fact that materials, in general, have defects. Though often regarded as detrimental and undesired due to the fact that they perturb the peculiar material’s properties, defects have also been exploited for introducing novel functionalities in (opto)electronic devices, and are being regarded as chemically-active sites suitable for the chemical functionalization of 2D materials, among which graphene and ultrathin TMDs. In the case of exfoliated 2D sheets, topological and structural defects can be inherited from the source bulk crystals, and they can also be generated during the exfoliation process. In CVD films, the synthesis/growth leads not only to point defects,
but also to grain boundaries (GBs), which affect the charge-transport properties in 2D electronic devices.\textsuperscript{156, 56} Also in this context, MoS\textsubscript{2} is the most studied among the TMD crystals.\textsuperscript{69} Its defects and their influences on various physical properties have been extensively investigated, both experimentally\textsuperscript{157-167} and theoretically.\textsuperscript{165, 168-174} In comparison, a relatively smaller number of works have focused on other TMDs, and in particular MoWSe\textsubscript{S} materials.\textsuperscript{172, 175-180}

Vacancies are a common type of point defects in ultrathin TMD samples and have been found in multiple forms — e.g. single or double, M or X vacancies — as recently reviewed by Lin \textit{et al.}\textsuperscript{69} In the case of MoS\textsubscript{2} monolayers prepared by micromechanical cleavage, aberration-corrected transmission electron microscopy (TEM) studies were reported in 2013 by Qiu \textit{et al.},\textsuperscript{157} who showed that sulfur vacancies (SVs) — see Fig. 2c and d — are the most abundant type of defects in exfoliated MoS\textsubscript{2} nanosheets, and can reach densities of the order of \(~10^{13}\) cm\textsuperscript{-2}, corresponding to approximately 10 SV over an area of 10\times10 nm\textsuperscript{2}. Two years later, Hong \textit{et al.},\textsuperscript{164} carried out a systematic TEM investigation and acquired statistical information on the quantities/types of defects in various MoS\textsubscript{2} samples. In agreement with the previous work,\textsuperscript{157} they found that single SVs (\(V_{S1}\)) can achieve concentrations as high as \(1.2\times10^{13}\) cm\textsuperscript{-2} in both mechanically-exfoliated and CVD-grown MoS\textsubscript{2} monolayers. Noticeably, double SVs (\(V_{S2}\)) were found to be present mainly in exfoliated nanosheets with densities in the range of \(~10^{12}\) cm\textsuperscript{-2}.\textsuperscript{164} The landscape of defects/disorder in CVD monolayer MoS\textsubscript{2} can be more complex, as shown by Zhou \textit{et al.}\textsuperscript{158} Besides the most abundant SVs, there are also GBs, dislocations, as well as different types of point defects, such as vacancies of Mo-S complexes and antisite defects.\textsuperscript{69, 158}

The variety and abundance of defects in MoS\textsubscript{2} and other TMDs is being regarded as a major problem to the implementation of practical and reliable (opto)electronic devices based on 2D semiconductors. However, defects can also be exploited to advantage for the chemical
functionalization of the ultrathin nanosheets. In fact, whereas the basal plane of pristine 2D TMDs lacks of dangling bonds and therefore is rather chemically inert, defect-rich surfaces allow for different chemical reactions to occur, as in the case of SV-containing MoS$_2$.\textsuperscript{109, 110, 181-186} It is worth noting that the edges of TMD crystals are also highly chemically reactive and have been widely investigated because of their excellent catalytic properties.\textsuperscript{187-191} Moreover, chalcogen- and metal-rich edges are being regarded as suitable targets for the chemical functionalization of liquid-phase exfoliated nanosheets (see Section 5),\textsuperscript{192-196} enabling the production of functional TMD inks for (opto)electronic\textsuperscript{197} as well as biomedical applications.\textsuperscript{198}

In the last few years, several defect-engineering strategies have been developed for tailoring the physico-chemical properties of 2D TMDs,\textsuperscript{69} opening new routes for the functionalization of TMDs \textit{via} molecular chemistry methods (Section 4.1).

1.2 “Bridging” ultrathin TMDs with molecular systems

Numerous advantages arise from the functionalization of ultrathin TMDs with molecular systems. Besides offering unique opportunities for tailoring the electrical, optical, thermal and sensing properties of TMDs, such a combination makes it also possible to develop novel multifunctional/multiresponsive hybrid materials and devices suitable for advanced logic, memory and sensing applications.\textsuperscript{199} Indeed, functionalization methods aiming at “bridging” these two worlds have been intensively investigated over the past few years.\textsuperscript{76, 111, 198, 200} In particular, molecular chemistry offers a variety of techniques to achieve this objective, as illustrated in Fig. 1. The simplest technique is based on the physisorption of electroactive molecules on substrate-supported nanosheets, which can be achieved \textit{via} solution-processing (\textit{e.g.} refs 87, 201) or vapour-phase (\textit{e.g.} ref. 202) deposition. A more elaborated approach consists in the use of the principles of supramolecular chemistry to control the ordering of molecules \textit{via} self-assembly.\textsuperscript{83, 203} Highly-ordered crystalline assemblies of physisorbed
molecules can be grown on 2D materials by drop casting or spin coating, resulting in spatially uniform periodic interactions between the 2D sheets and the molecular adlayers. In addition, the packing and orientation of the molecules can be engineered *ad hoc* in order to modulate the magnitude/direction of surface dipoles, as well as the charge transfer between the molecular layers and the 2D crystal. This represents an intriguing opportunity for tuning the charge-carrier doping in ultrathin TMDs, eventually by bringing into play cooperativity or collective processes. A slightly different technique involves the preparation of self-assembled monolayers (SAMs) via molecular chemisorption on suitable substrates, followed by the deposition/transfer of the 2D sheets (*e.g.* refs 84, 92). More in general, the TMDs’ electronic and optical properties can be tailored by controlling the substrate surface chemistry, which can be accomplished with multiple approaches, including the use of polymer coating layers.

In all the cases discussed above, the functionalization is achieved through non-covalent interactions between the molecules and the 2D sheets. However, it is also possible to “bridge” ultrathin TMDs and molecules *via* strong and stable covalent bonds, *e.g.* by exploiting defect and phase-engineering approaches to activate and harness the chemical reactivity of the TMDs’ surface. For instance, ultrathin layers of MoS$_2$ containing SVs can be “decorated” with molecules bearing nucleophilic functional groups — especially thiols — that can coordinate/bind to the exposed molybdenum atoms at SV sites. Whereas the semiconducting 1H/2H phase of MoS$_2$ cannot be easily functionalized in the absence of defects, its electron-rich 1T/1T’ counterpart allows for numerous functionalization routes, since the occurrence of bond-forming reactions is facilitated by electron transfer between the metallic sheets and the reactant species (*e.g.* electrophiles such as organohalides). Hence, one can exploit phase-conversion processes in TMDs (see Section 1.1) to obtain metallic polytypes suitable for chemical functionalization, and eventually
convert them back to their original phase, as demonstrated by Voiry et al. Noticeably, all these approaches can be conducted directly in solution — e.g. in the case of liquid-phase exfoliated TMDs (Section 5) — or on substrate-supported sheets, as outlined in detail below.

2. Tuning the properties of TMDs via non-covalent interactions

In conventional semiconductor technology, precise control over the optoelectronic properties of materials can be achieved by substitutional doping, which consists in replacing host atoms of the crystal with dopant impurities. In ultrathin TMDs, doping can be accomplished by decorating their surface with electroactive (i.e. donor or acceptor) molecules, which can be used to controllably tune the charge-carrier density through diverse electromagnetic interactions (e.g. electrostatic and van der Waals). Indeed, the ultra-high surface-to-volume ratio in 2D TMDs makes their optoelectronic properties extremely sensitive to any variation in their surface environment. While substitutional doping has also been successfully applied to TMDs, the non-covalent molecular approach (i.e. physisorption) has the advantage of leaving the crystal structure of TMDs unaltered, preserving their superior optoelectronic properties.

Two major mechanisms lead to the molecular doping of TMDs, which are (i) charge transfer and (ii) dipolar interactions. Charge transfer occurs when the electrochemical redox potential of the molecules and the Fermi level of 2D materials comply with certain conditions. When the redox potential of a given molecular dopant lies below the TMD Fermi level, electron transfer can occur from the TMD sheet to the molecule, resulting in p-type doping. Vice versa, when the redox potential of molecules lies above the TMD Fermi level, electrons are transferred from the molecules to the TMD, inducing n-type doping. Fig. 3 compares the reduction potentials of various molecular dopants with the band edges — namely the electron affinity (conduction band minimum, CBM) and the ionization potential (valence band maximum, VBM) — of group-6 monolayer TMDs. Although the exact Fermi level position
of TMDs depends on several factors (e.g. impurities, substrate, crystal defects, etc.), the figure provides a guideline for the choice of suitable molecules to realize doping in monolayer TMD sheets based on possible charge-transfer processes involving the CBM/VBM levels of TMDs. It should be noticed that the band edges are characterized by a significant uncertainty; for instance, the electron affinity of 1L MoS\(_2\) has been reported to vary from \(\sim 3.9\) eV (ref. 211) to \(\sim 4.7\) eV (ref. 212).

Dipolar interactions can also be exploited for tuning the charge-carrier doping in ultrathin TMDs. Molecules with permanent dipole moments generate electric fields on the 2D-sheet surface, modulating the (local) charge carrier density similarly to nanoscopic electric gates. If the dipole moments of several molecules lying on the TMD surface possess the same spatial orientation, single-molecule effects can sum up leading to a macroscopic modification of the TMD energetics. In particular, a shift in the Fermi level of semiconducting TMDs was observed as a consequence of the interaction with well-aligned molecular dipoles,\(^{84}\) resulting in \(p\)- or \(n\)- type doping depending on the dipole direction.\(^{86}\) In most cases, both mechanisms contribute to the doping effect, and it is often difficult to disentangle the two contributions.\(^{92}\)

In this section, we will summarize the doping of TMDs through the decoration of their top and bottom surfaces with electroactive molecular systems. As an overview, Table 1 provides a summary of the molecules that have been used to decorate ultrathin TMDs, highlighting their impact on the optoelectronic and vibrational properties, as well as the mechanisms responsible for the measured effects.
Table 1. Effects of molecular dopants on the electronic (doping), vibrational ($A_{1g}$, and $E_{12g}$ Raman modes) and optical (PL) properties of substrate-supported ultrathin TMDs. Notes: CT, charge transfer; DI, dipolar interactions; PI-CT, photo-induced charge transfer; RS, red shift; BS, blue shift; FWHM, full width at half maximum. (*) TMD coated with a hybrid PMMA/F$_4$-TCNQ layer.

<table>
<thead>
<tr>
<th>Ref.</th>
<th>Molecules</th>
<th>TMD</th>
<th>Doping mechanisms</th>
<th>Doping type</th>
<th>Doping density $\Delta Q/e$ [cm$^{-2}$]</th>
<th>Effect on PL</th>
<th>Effect on Raman modes</th>
<th>Functional group interacting with TMDs</th>
<th>Stability</th>
<th>Deposition method</th>
</tr>
</thead>
<tbody>
<tr>
<td>85</td>
<td>benzyl viologen (BV)</td>
<td>MoS$_2$</td>
<td>CT</td>
<td>$n$</td>
<td>$\sim 10^{13}$</td>
<td>$A_{1g}$ RS, FWHM ↑</td>
<td>$A_{1g}$</td>
<td>9 days</td>
<td>drop cast or soaking</td>
<td></td>
</tr>
<tr>
<td>209</td>
<td>nicotinamide adenine dinucleotide (NADH)</td>
<td>MoS$_2$</td>
<td>CT</td>
<td>$n$</td>
<td>RS, I ↓</td>
<td>-NH$_2$</td>
<td>drop cast</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>88</td>
<td>mercaptoethylamine (MEA)</td>
<td>MoS$_2$</td>
<td>CT</td>
<td>$n$</td>
<td>$3.7 \times 10^{12}$</td>
<td>RS, I ↓</td>
<td>-NH$_2$</td>
<td>1 week</td>
<td>soaking</td>
<td></td>
</tr>
<tr>
<td>94</td>
<td>polyethyleneimine (PEI)</td>
<td>MoS$_2$</td>
<td>CT</td>
<td>$n$</td>
<td></td>
<td></td>
<td>-NH$_2$</td>
<td>unstable</td>
<td>soaking</td>
<td></td>
</tr>
<tr>
<td>101</td>
<td>triphenylphosphine (PPh$_3$)</td>
<td>MoS$_2$</td>
<td>CT</td>
<td>$n$</td>
<td>$1.6 \times 10^{11}$</td>
<td></td>
<td>$A_{1g}$, $E_{12g}$ RS, $A_{1g}$ FWHM ↑</td>
<td>14 days</td>
<td>spin-coating</td>
<td></td>
</tr>
<tr>
<td>213</td>
<td></td>
<td>ReSe$_2$</td>
<td>CT</td>
<td>$n$</td>
<td>$1.1 \times 10^{11}$</td>
<td></td>
<td>$A_{2g}$, $E_{2g}$ RS, $A_{3g}$ FWHM ↑</td>
<td>14 days</td>
<td>spin-coating</td>
<td></td>
</tr>
<tr>
<td></td>
<td></td>
<td>WSe$_2$</td>
<td>CT</td>
<td>$n$</td>
<td>$7.8 \times 10^{11}$</td>
<td></td>
<td>$A_{3g}$, $E_{12g}$ BS</td>
<td>8 days</td>
<td>spin-coating</td>
<td></td>
</tr>
<tr>
<td>214</td>
<td>hydrazine</td>
<td>WSe$_2$</td>
<td>CT</td>
<td>$n$</td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>88</td>
<td>1H,1H,2H,2H-perfluorodecanethiol (FDT)</td>
<td>MoS$_2$</td>
<td>CT</td>
<td>$n$</td>
<td>$1.8 \times 10^{11}$</td>
<td>BS, I ↑</td>
<td></td>
<td>-CF$_3$</td>
<td>soaking</td>
<td></td>
</tr>
<tr>
<td>209</td>
<td>tetracyanoquinodimethane (TCNQ)</td>
<td>MoS$_2$</td>
<td>CT</td>
<td>$p$</td>
<td></td>
<td>BS, I ↑</td>
<td></td>
<td></td>
<td>drop cast</td>
<td></td>
</tr>
<tr>
<td>No.</td>
<td>Material Description</td>
<td>Material</td>
<td>Spin-Coating Type</td>
<td>Thickness</td>
<td>Spin-Coating Fluid</td>
<td>Modification</td>
<td>Source</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>-----</td>
<td>-----------------------------------------------------------------------------------</td>
<td>----------</td>
<td>-------------------</td>
<td>-----------</td>
<td>-------------------</td>
<td>--------------</td>
<td>--------</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>209</td>
<td>tetrafluoro-7,7,8,8-tetracyanoquinodimethane (F&lt;sub&gt;4&lt;/sub&gt;-TCNQ)</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>CT</td>
<td>p</td>
<td>5.8×10&lt;sup&gt;13&lt;/sup&gt;</td>
<td>BS, I↑</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td></td>
<td>WSe&lt;sub&gt;2&lt;/sub&gt;</td>
<td>CT</td>
<td>p</td>
<td>7.4×10&lt;sup&gt;13&lt;/sup&gt;</td>
<td>BS, I↑</td>
<td>A&lt;sub&gt;1g&lt;/sub&gt;, BS</td>
<td>-F</td>
<td>2 weeks</td>
<td></td>
<td></td>
</tr>
<tr>
<td>215</td>
<td>magnesium phthalocyanine (MgPc)</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>PI-CT</td>
<td>p</td>
<td>I↓</td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>216</td>
<td>WSe&lt;sub&gt;2&lt;/sub&gt;</td>
<td>PI-CT</td>
<td>p</td>
<td>I↓</td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>99</td>
<td>nickel phthalocyanine (NiPc)</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>PI-CT</td>
<td>p</td>
<td>I↓</td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td></td>
<td>WSe&lt;sub&gt;2&lt;/sub&gt;</td>
<td>PI-CT</td>
<td>p</td>
<td>I↓</td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>217</td>
<td>titanyl phthalocyanine (TiOPc)</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>CT</td>
<td>p</td>
<td>I↑</td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td></td>
<td>WSe&lt;sub&gt;2&lt;/sub&gt;</td>
<td>DI</td>
<td>p</td>
<td>I↑</td>
<td>A&lt;sub&gt;3g&lt;/sub&gt;, E&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>I↑</td>
<td>100 hours</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td></td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>DI</td>
<td>p</td>
<td>I↑</td>
<td>A&lt;sub&gt;3g&lt;/sub&gt;, E&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>I↑</td>
<td>100 hours</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td></td>
<td>WSe&lt;sub&gt;2&lt;/sub&gt;</td>
<td>DI/CT</td>
<td>n</td>
<td>I↑</td>
<td>A&lt;sub&gt;3g&lt;/sub&gt;, E&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>I↑</td>
<td>100 hours</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>39</td>
<td>octadecytrichlorosilane (ODTS)</td>
<td>WSe&lt;sub&gt;2&lt;/sub&gt;</td>
<td>DI/CT</td>
<td>n</td>
<td>1.1×10&lt;sup&gt;11&lt;/sup&gt;</td>
<td>A&lt;sub&gt;3g&lt;/sub&gt;, E&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>I↑</td>
<td>100 hours</td>
<td></td>
<td></td>
</tr>
<tr>
<td></td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>DI/CT</td>
<td>n</td>
<td>1×10&lt;sup&gt;11&lt;/sup&gt;</td>
<td>A&lt;sub&gt;3g&lt;/sub&gt;, E&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>I↑</td>
<td>100 hours</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>81</td>
<td>oleylamine</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>DI/CT</td>
<td>n</td>
<td>1.8×10&lt;sup&gt;13&lt;/sup&gt;</td>
<td>A&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>I↑</td>
<td>100 hours</td>
<td></td>
<td></td>
</tr>
<tr>
<td></td>
<td>WSe&lt;sub&gt;2&lt;/sub&gt;</td>
<td>DI/CT</td>
<td>n</td>
<td>1.8×10&lt;sup&gt;13&lt;/sup&gt;</td>
<td>A&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>I↑</td>
<td>100 hours</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>102</td>
<td>methyl salicylate</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>CT</td>
<td>n</td>
<td>I↑</td>
<td>A&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>spin-coating</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>218</td>
<td>perylenediimides</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>CT</td>
<td>n</td>
<td>I↑</td>
<td>A&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>spin-coating</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>218</td>
<td>tetraphenyl porphyrins</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>CT</td>
<td>n</td>
<td>I↑</td>
<td>A&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>spin-coating</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>102</td>
<td>benzoic acid</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>CT</td>
<td>n</td>
<td>I↑</td>
<td>A&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>spin-coating</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>102</td>
<td>phenol</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>CT</td>
<td>n</td>
<td>I↑</td>
<td>A&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>spin-coating</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>102</td>
<td>salicylic acid</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>CT</td>
<td>n</td>
<td>I↑</td>
<td>A&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>spin-coating</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>102</td>
<td>nitrobenzene</td>
<td>MoS&lt;sub&gt;2&lt;/sub&gt;</td>
<td>CT</td>
<td>n</td>
<td>I↑</td>
<td>A&lt;sub&gt;1g&lt;/sub&gt;</td>
<td>spin-coating</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>Compound/Coating</td>
<td>Material</td>
<td>Thickness</td>
<td>Current Density</td>
<td>Current Path</td>
<td>Interleaved</td>
<td>ION/AIR</td>
<td>FWHM下的退化</td>
<td>Note</td>
<td></td>
<td></td>
</tr>
<tr>
<td>-------------------------------------</td>
<td>----------</td>
<td>-----------</td>
<td>-----------------</td>
<td>--------------</td>
<td>-------------</td>
<td>---------</td>
<td>----------------</td>
<td>------</td>
<td></td>
<td></td>
</tr>
<tr>
<td>aniline MoS₂</td>
<td>p</td>
<td>I↑</td>
<td>A₁₈ BS</td>
<td>-NH₂</td>
<td>spin-coating</td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>melamine MoS₂</td>
<td>p</td>
<td>I↑</td>
<td>A₁₈ BS</td>
<td>-NH₂</td>
<td>spin-coating</td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>fluorinated fullerene (C₆₀F₄₈)</td>
<td>WSe₂</td>
<td>CT</td>
<td>p</td>
<td>1×10¹²</td>
<td>F</td>
<td>evaporation</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>octyltrichlorosilane (OTS)</td>
<td>MoS₂</td>
<td>DI</td>
<td>none</td>
<td>none</td>
<td>none</td>
<td>none</td>
<td>none</td>
<td>-CH₃</td>
<td></td>
<td></td>
</tr>
<tr>
<td>octadecltrichlorosilane (ODTS)</td>
<td>MoS₂</td>
<td>DI</td>
<td>p</td>
<td>5×10¹¹</td>
<td>none</td>
<td>none</td>
<td>none</td>
<td>-CH₃</td>
<td></td>
<td></td>
</tr>
<tr>
<td>DNA MoS₂</td>
<td>MoS₂</td>
<td>DI</td>
<td>n</td>
<td>6×10¹⁰</td>
<td>A₁₃g E¹₂g BS</td>
<td>phosphate</td>
<td>drop cast</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>metal DNA WSe₂</td>
<td>WSe₂</td>
<td>DI</td>
<td>n</td>
<td>7×10⁹</td>
<td>A₁₃g E¹₂g BS</td>
<td></td>
<td>drop cast</td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>tris(4-bromophenyl)ammoniumyl hexachloroantimonate (Magic Blue) MoS₂</td>
<td>CT</td>
<td>p</td>
<td>8×10¹²</td>
<td>A₁₃g E¹₂g BS</td>
<td>dip coating</td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>2-ferrocenyl N,N'-dimethylbenzimidazoline ((2-Fc-DMBI)₂) MoS₂</td>
<td>CT</td>
<td>n</td>
<td>6.3×10¹²</td>
<td>A₁₃g E¹₂g RS</td>
<td>dip coating</td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>2-ferrocenyl-2,3-dihydro-1H-benzimidazoline (2-Fc-DMBI-H) MoS₂</td>
<td>CT</td>
<td>n</td>
<td>5.2×10¹²</td>
<td>A₁₃g E¹₂g RS</td>
<td>dip coating</td>
<td></td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
</tbody>
</table>

**Decoration of the bottom surface**

<table>
<thead>
<tr>
<th>Compound/Coating</th>
<th>Material</th>
<th>Thickness</th>
<th>Current Density</th>
<th>Current Path</th>
<th>Interleaved</th>
<th>ION/AIR</th>
<th>FWHM下的退化</th>
<th>Note</th>
</tr>
</thead>
<tbody>
<tr>
<td>3-(trimethoxysilyl)-1-propanamine (APTES) MoS₂</td>
<td>DI</td>
<td>n</td>
<td>1×10¹¹</td>
<td>I↑</td>
<td>A₁₃g RS, FWHM↑</td>
<td>-NH₂</td>
<td>SAM</td>
<td></td>
</tr>
<tr>
<td>trichloro-(1H,1H,2H,2H- perfluoroocetyl)ilane (FOTS) MoS₂</td>
<td>DI/CT</td>
<td>n</td>
<td>8×10¹¹</td>
<td>A₁₃g BS, FWHM↓</td>
<td>-CF₃</td>
<td>SAM</td>
<td></td>
<td></td>
</tr>
<tr>
<td>(3-mercaptopropyl)trimethoxysilane (MPS) MoS₂</td>
<td>DI/CT</td>
<td>n</td>
<td>1×10¹¹</td>
<td>I↑</td>
<td>none</td>
<td>none</td>
<td>none</td>
<td></td>
</tr>
<tr>
<td>(E)-6-(4-(phenyl diazenyl)phenoxy)hexane-1-thiol (HS-C₆AzO) MoS₂</td>
<td>DI/CT</td>
<td>n</td>
<td>1×10¹¹</td>
<td>I↑</td>
<td>none</td>
<td>none</td>
<td>none</td>
<td></td>
</tr>
<tr>
<td>(E)-6-(4-(4-chlorophenyl) diazenyl) phenoxy)hexane-1-thiol (HS-C₆AzO-CI) MoS₂</td>
<td>DI/CT</td>
<td>p</td>
<td>I↑</td>
<td>-Cl</td>
<td>SAM</td>
<td></td>
<td></td>
<td></td>
</tr>
</tbody>
</table>
2.1 Physisorption of electroactive molecules

Crystal defects and impurities introduced with conventional doping techniques can significantly affect the electrical characteristics of FETs based on monolayer TMDs, including the field-effect mobility, the threshold voltage and the subthreshold swing. Moreover, they can degrade the performances of optoelectronic devices in terms of photoresponsivity and light emission. The physisorption of electroactive molecules on the surface of ultrathin TMD sheets represents an alternative non-destructive method for tuning doping via charge transfer, as discussed previously. One of the most studied molecules is 2,3,5,6-tetrafluoro-7,7,8,8-tetracyanoquinodimethane (F$_4$-TCNQ), which is a common electron acceptor ($p$-dopant). The redox potential of F$_4$-TCNQ lies below the CBM of monolayer MoS$_2$ (see Fig. 3) so that electron transfer can occur from the conduction band of heavily $n$-doped MoS$_2$ — where the Fermi level lies close to the CBM — to the unoccupied energy states of the F$_4$-TCNQ molecules, resulting in electron depletion. The $p$-doping effect is evident from the evolution of the photoluminescence (PL) spectra upon molecular physisorption (Fig. 4a). The A exciton, which is associated with optical transitions at the K point of the Brillouin zone, consists of both negatively-charged excitons (i.e. trions, $E(X^-) \approx 1.84$ eV) and neutral excitons ($E(X) \approx 1.88$ eV), so that the trion spectral weight depends on the amount of doping in the 2D semiconducting sheet. For the as-exfoliated MoS$_2$, the trion intensity was found to be higher than that of the neutral exciton (see fitting in Fig. 4c) due to the $n$-type doping typically occurring in natural MoS$_2$ crystals. On the other hand, in the F$_4$-TCNQ-doped MoS$_2$ the contribution of the neutral exciton becomes dominant due to electron depletion, the A peak blue shifts and its intensity increases dramatically.

Different from F$_4$-TCNQ, nicotinamide adenine dinucleotide (NADH) has a redox potential higher than the CBM of monolayer MoS$_2$ (see Fig. 3) and therefore can be used for $n$-type doping. After physisorption of NADH molecules, the PL spectra of monolayer MoS$_2$ (Fig. 4b)
are characterized by a higher trion spectral weight. Moreover, the A peak red-shifts and its intensity decreases, due to electron accumulation in the 2D material. Hence, through the molecular physisorption approach both the charge-carrier doping and the PL emission spectra can be effectively modulated.

Similar results were obtained by Peimyoo et al.\textsuperscript{216} by making use of monolayer (1L) WS\textsubscript{2} sheets in combination with F\textsubscript{4}-TCNQ molecules. The authors investigated the effects of molecular physisorption on the electrical properties of back gated 1L-WS\textsubscript{2} FETs (Fig. 4d). With increasing F\textsubscript{4}-TCNQ concentration, the threshold voltage was found to shift towards more positive gate-voltage values in line with the occurrence of \textit{p}-type doping.

Besides PL and charge-transport measurements, Raman spectroscopy is also a versatile tool for studying doping effects in TMDs.\textsuperscript{227} The two main Raman-active phonon modes of 2H-TMD crystals are \textit{A}\textsubscript{1g} and \textit{E}\textsubscript{2g}, which correspond to out-of-plane vibrations of chalcogen atoms and in-plane vibrations of chalcogen and transition metal atoms, respectively.\textsuperscript{228} Density functional theory (DFT) calculations and symmetry arguments predict that for MoS\textsubscript{2}, the \textit{A}\textsubscript{1g} phonon mode is more sensitive to the electron doping than the \textit{E}\textsubscript{2g} mode due to a stronger electron-phonon coupling in the out-of-plane \textit{A}\textsubscript{1g} vibration.\textsuperscript{227} Raman spectra of few-layer MoS\textsubscript{2} sheets were measured after “decoration” with \textit{n}-type and \textit{p}-type dopant molecules, as illustrated in Fig. 5.\textsuperscript{87} For the \textit{n}-type dopant (2-Fe-DMBI\textsubscript{2} \textemdash \textit{i.e.} 2-ferrocenyl N,N'-dimethylbenzimidazoline radical, inset of Fig. 5b \textemdash the \textit{A}\textsubscript{1g} peak of MoS\textsubscript{2} red-shifts by \textasciitilde1 cm\textsuperscript{-1} and the peak broadens (\textit{ΔFWHM} \textasciitilde 1.4 cm\textsuperscript{-1}), whereas the \textit{E}\textsubscript{2g} mode remains almost unchanged (\textit{Δυ} \textless 0.2 cm\textsuperscript{-1}, Fig. 5b). In contrast, for \textit{p}-type dopants such as tris(4-bromophenyl)ammoniumyl hexachloroantimonate (“Magic Blue”, Fig. 5d) both \textit{A}\textsubscript{1g} and \textit{E}\textsubscript{2g} peak blue-shift (\textit{Δυ} \textasciitilde 0.5 cm\textsuperscript{-1}) and the peak sharpens (\textit{ΔFWHM} \textasciitilde -0.4 cm\textsuperscript{-1}). The effects of molecular physisorption doping on the Raman spectra of MoS\textsubscript{2} nanosheets are similar to those induced by electrostatic gating in FET structures.\textsuperscript{227} With the increasing gate voltage (electron
doping), the $A_{1g}$ peak red-shifts and the peak broadens. This demonstrates that molecular physisorption influence phonon vibrations by modifying electron-phonon interactions. Furthermore, the shift of the $A_{1g}$ Raman peak is proportional to the doping concentration,\textsuperscript{227} which is quite useful to probe the doping level in TMDs.

Numerous molecules have been exploited to tune the properties of TMDs.\textsuperscript{25,36} Among these, we discuss a class of metallophthalocyanine molecules — indicated as MPc, where M is the metal centre (\textit{e.g.} NaPc, MgPc, TiPc, FePc, NiPc, CuPc, PtPc, \textit{etc.}) — which are currently attracting attention for doping TMDs due to their metal-centre dependent redox potential.\textsuperscript{99} A schematic illustration of a MPc molecule physisorbed on a TMD sheet is provided in Fig. 6a. The planar structure of $\pi$-conjugated rings results in a flat-lying MPc/TMD configuration. Based on the positions of the band edges of TMDs with respect to the redox potential of MPcs, it is possible to predict the direction of the charge transfer between the TMDs and the MPc molecules.\textsuperscript{99} For example, the redox potential of NiPc (MgPc) is located below (above) the CBM of MoSe$_2$ (Fig. 3). Upon light irradiation, photo-excited electrons in the conduction band of MoSe$_2$ can transfer to NiPc molecules, which provide a non-radiative recombination pathway that severely degrades the PL quantum yield of monolayer MoSe$_2$ (Fig. 6b). In contrast, no significant changes can be observed in the PL spectra of MgPc-treated MoSe$_2$ (Fig. 6c).\textsuperscript{99} Physisorbed MPc molecules can be effectively used for tuning the charge-carrier density in ultrathin TMD sheets. For instance, NaPc induces $n$-type doping in MoS$_2$ whereas FePc and CuPc result in $p$-type doping.\textsuperscript{89} Interestingly, the charge-carrier density in hybrid MPc/TMD systems depends on the work function of the MPc metal centre, which can therefore be chosen \textit{ad hoc} for achieving the desired level of doping. It is worth noting that MPc/MoS$_2$ FETs were found to be stable for at least two weeks after doping, despite the lack of any encapsulation layer. Finally, physisorbed MPc molecules have been investigated for
passivating electronic defects, as well as for engineering surface states in defective monolayer MoS\textsubscript{2}.\textsuperscript{217}

The effects of organic dyes on the optoelectronic properties of TMDs were recently explored.\textsuperscript{218,229} In particular, perylenediimides and tetraphenyl porphyrins allowed increasing the conductivity of bottom-contact back-gate photodetectors based on relatively thick MoS\textsubscript{2} sheets (approximately 10-layers)\textsuperscript{218} Such an increase was ascribed to the \textit{n}-type doping induced by physisorbed molecules.

All these results demonstrate the possibility to control the charge-carrier doping in TMDs by molecular physisorption. However, further research is required to improve the stability of the charge transport properties in hybrid TMD-molecule systems, \textit{e.g.} by developing suitable encapsulation techniques to prevent desorption or eventual decomposition of molecules during device operation and storage. Towards this goal, novel approaches are being explored. For instance, Yu \textit{et al.}\textsuperscript{215} reported on the use of mixtures of poly(methyl methacrylate) (PMMA) and F\textsubscript{4}-TCNQ for simultaneously doping and encapsulating few-layer WSe\textsubscript{2} FETs.

2.2 Molecular engineering of the top and bottom TMD surface

In this section, we highlight how molecular decoration enables significant engineering of TMDs also in the absence of strong covalent interactions and significant charge transfer. When organized in continuous and homogeneous layers, even inert molecules can modify the TMD optoelectronic properties, by acting as passivating/encapsulating agents\textsuperscript{230} or by interacting through (ordered) dipolar fields.\textsuperscript{39}

In particular, the bottom TMD surface has been modified through a highly controllable molecular tuning of the physico-chemical properties of the substrate surface. This goal was achieved by inserting polymers or chemisorbed SAMs between the substrate and the TMDs. Instead, the top TMD surface is affected by the presence of highly ordered physisorbed layers
composed of functional molecules. We highlight that whenever ordered monolayers are employed, the collective interaction between molecules and 2D materials is determined by the nanoscale molecular ordering. Precise control over the molecular arrangement at the nanoscale can thereof be exploited to finely tune the TMD optoelectronic properties. In this regard, the electrical and optical characterization of TMD/molecules systems should be ideally complemented by scanning tunnelling microscopy (STM) investigations, which offers the possibility to explore molecular adsorption with sub-molecular structural and functional resolution.\textsuperscript{231-234} In this way, STM could provide precious insights into the molecular-scale mechanisms leading to macroscopic effects, permitting not only to control the nanoscale assembly, but also to guide in the program and design of molecular units exhibiting the desired cooperative or collective effects. This possibility will be discussed in more detail in the conclusion section.

**TMDs on polymers and functional SAMs.** Polymers have often been employed as dielectric substrates for TMDs,\textsuperscript{205, 206, 235-237} in view of their mechanical flexibility that makes them compatible with bendable and stretchable electronics.\textsuperscript{47, 238, 239} As compared to conventional SiO\textsubscript{2}, dielectric polymer films can be remarkably different in terms of surface roughness, dielectric permittivity and phonon vibrations.\textsuperscript{205, 240, 241} Molecular design can be exploited to tailor the physico-chemical properties of polymeric surfaces, \textit{e.g.} enabling a precise tuning of the surface energy.\textsuperscript{242} Hereafter, we present a few examples in which polymer-modified substrates result in a significant improvement of the (opto)electronic properties of TMDs.

Fig. 7a displays the general scheme of a typical FET based on TMD sheets deposited onto a dielectric polymer substrate. By using this architecture, Chamlagain \textit{et al.}\textsuperscript{205} demonstrated that the room-temperature field-effect mobility of multilayer (5-15 nm thick) MoSe\textsubscript{2} FETs on parylene (100-150 cmV\textsuperscript{-1}s\textsuperscript{-1}) was systematically higher than in the case of equivalent devices on SiO\textsubscript{2} (~50 cmV\textsuperscript{-1}s\textsuperscript{-1}, Fig. 7b). The authors attributed such substrate dependent mobility to
different phonon vibrations at the SiO$_2$ and parylene surfaces. In particular, the scattering with polar optical phonons originating from the substrate limits the mobility of MoSe$_2$ on SiO$_2$, while it is nearly absent for MoSe$_2$ on parylene.$^{205}$ Alternative explanations for the measured effects include the polymer-mediated passivation of charged impurities on the SiO$_2$ surface and a partial leveraging of the TMD layer due to the polymer roughness, which helps the removal of adsorbate molecules trapped below the bottom TMD surface during vacuum annealing. Similarly, the electronic performances of multilayer MoS$_2$ on PMMA were found to be higher than those on SiO$_2$. Remarkably, in the case of MoS$_2$ on PMMA not only high $n$-type mobility was measured (up to $\sim$470 cm$^2$/Vs) but also $p$-type mobility (up to $\sim$480 cm$^2$/V$^s^{-1}$), resulting in almost ideal ambipolar characteristics. The different electronic behavior of MoS$_2$ on SiO$_2$ and PMMA was attributed to short range disorder at the TMD/SiO$_2$ interface (e.g. roughness scattering).$^{236}

In a recent study, Liu et al.$^{206}$ found that the PL spectrum of MoS$_2$ onto the fluoropolymer CYTOP closely resembles that of self-standing MoS$_2$ with a narrow and strong PL peak at the region of A exciton and without trion peak (Fig. 7c). A similar effect was observed for WS$_2$. FETs fabricated on MoS$_2$ monolayers on CYTOP also showed lower intrinsic $n$-type doping and higher mobility than those fabricated on SiO$_2$. In view of these results, the authors conclude that CYTOP is an ideal substrate for TMDs, on account of its very low surface energy, low surface trap densities and low permittivity. By taking full advantage of the polymeric substrate, the authors demonstrate a giant bandgap renormalization in back-gated MoS$_2$ and WS$_2$, which manifests itself as a sizeable gate-induced modulation of PL and differential reflectance (Fig. 7d).$^{206}$

These examples show how TMD/substrate interactions, which remarkably influence the charge-transport properties of TMDs,$^{243}$ can be tuned by making use of polymeric substrates, thereby offering a valuable strategy to engineer TMD-based devices.
Similarly, the physico-chemical properties of the substrate can be tailored by using functional SAMs chemisorbed on solid substrates.\textsuperscript{244} The molecules employed to generate such architectures possess (i) an anchoring group that promotes the chemisorption onto the substrate, (ii) a molecular backbone that stabilizes the packing \textit{via} side-to-side molecular interactions, and (iii) a functional headgroup that ultimately determines the physico-chemical characteristics of the exposed surface.\textsuperscript{245} TMDs can be deposited onto SAM-modified surfaces (\textit{e.g.} Fig. 8a) and they display different properties depending on the molecular headgroups in the SAM. We point out that while SAMs are covalently bound to the substrate, TMD sheets are physisorbed onto SAMs and their interaction is mediated by relatively weak van der Waals forces. Crucially, non-covalent interactions among adjacent molecules forming the SAM endow high crystalline order with molecules oriented edge-on with respect to the substrate plane.\textsuperscript{244} In this way, the ordered nanoscale arrangement ensures that single-molecule dipoles sum up, collectively generating significant electric fields. Therefore, when TMDs are exfoliated onto SAM-decorated substrates, they experience an electric field effect analogous to that generated by a constant non-zero gate voltage. As a result, highly ordered SAMs of high-dipole molecules can introduce significant shifts in the Fermi level of TMDs,\textsuperscript{84} resulting in doping effects that are mediated by purely electrostatic interaction, even in the absence of significant charge transfer. The two doping mechanisms – \textit{i.e.} charge transfer\textsuperscript{82, 87} or dipolar interactions\textsuperscript{87, 246} – are often concomitant, and it is not always possible to completely disentangle one from the other.\textsuperscript{87, 92}

Experimentally, the possibility to modulate the charge carrier concentration \textit{via} SAMs was demonstrated in a study of the optoelectronic characteristics of mechanically-exfoliated MoS\textsubscript{2} sheets deposited onto different SAMs.\textsuperscript{84} The authors modified the SiO\textsubscript{2} substrate employing SAMs composed of alkanes exposing an anchoring silane group and different functional headgroups. In particular, SAMs of three silane agents characterized by different dipole
moments and polarities were employed: octyltrichlorosilane (OTS, CH$_3$-SAM), 3-
(trimethoxysilyl)-1-propanamine (APTES, NH$_2$-SAM), and trichloro-(1H,1H,2H,2H-
perfluorooctyl)silane (FOTS, CF$_3$-SAM), as shown in Fig. 8a. The arrangement of the
different molecules, which plays a fundamental role in the determination of the measured
effects, was indirectly inferred on the basis of the surface energy of the SAMs, as measured
by water contact angle. The effect of the different molecular dipoles on the optoelectronic
properties of MoS$_2$ was investigated by a combination of Raman spectroscopy, FET
fabrication and characterization, as well as Kelvin probe force microscopy (KPFM)
measurements. Fig. 8b shows the electrical characterization of FETs based on a few-layers
MoS$_2$ fabricated on the different SAMs. The FOTS SAM was found to induce a positive shift
of the threshold voltage, i.e. it introduces $p$-type doping. On the other hand, the APTES SAM
was found to introduce a shift of the threshold voltage towards more negative gate values, i.e.
introduce $n$-type doping. Through KPFM, the authors showed that the position of the Fermi
level of monolayer MoS$_2$ could be modulated in a range of more than 0.45 eV by the
electrostatic interaction with FOTS and APTES. Finally, minor effects on the threshold
voltage were observed for the OTS SAM as compared to the bare SiO$_2$ substrate, indicating
minor doping. These results were explained on the basis of the different orientation of the
(well-aligned) molecular dipoles, which point towards opposite directions for FOTS and
APTES. Instead, the relatively low dipolar moment of CH$_3$ did not induce significant doping
on MoS$_2$. Nevertheless, even alkyl SAMs have interesting effects on the optoelectronic
properties of TMDs. Recently, Ajayi et al.$^{230}$ measured an ultranarrow low-temperature PL
linewidth in MoSe$_2$ (approaching the intrinsic limit) thanks to an effective substrate
passivation achieved via alkyl SAMs. In particular, a 6-meV-wide PL peak was measured for
MoSe$_2$ on the alkyl SAM, in contrast to the broader 9-meV peak of MoSe$_2$ on SiO$_2$.
Additionally, the presence of the alkyl SAM also affected the optical characteristics of MoSe$_2$
encapsulated in BN (BN/MoSe$_2$/BN), which exhibited broader PL on the bare SiO$_2$ (3meV) rather on the SAM-passivated surface (2 meV).

Theoretically, it was predicted that the presence of SAMs exposing a polar headgroup (both –CH$_3$ and –CF$_3$) anchored onto metal electrodes could promote the charge injection into MoSe$_2$, converting Schottky metal-semiconductor junctions into nearly Ohmic contacts.$^{95}$ These studies show how SAM engineering represents a straightforward approach to control the charge-carrier polarity enabling the fabrication of $p$-$n$ junctions and complementary logic devices.

Taking a step further, a thorough choice of the molecules composing the SAMs makes it possible to confer unique SAM-derived capabilities to TMDs. This possibility was demonstrated by depositing MoS$_2$ onto a photoswitchable SAM composed of a thiolated photochromic azobenzene (AZO) moiety ((E)-6-(4-(phenyldiazenyl) phenoxy)hexane-1-thiol, HS-C$_6$AZO) chemisorbed on a gold substrate (Fig. 8c).$^{222,247}$ AZO are photochromic molecules which can be switched between a trans and a cis isomer upon light irradiation at different wavelengths (Fig. 8c).$^{248}$ When AZO molecules self-assemble forming ordered chemisorbed monolayers on metals, the photoswitch is accompanied by a modification of the surface energetics,$^{249-251}$ which is in turn reflected by a change of the optical properties of MoS$_2$ monolayers.$^{222}$ In particular, lower (higher) PL intensity was measure when the AZO-SAM was in the trans (cis) state, which was explained in terms of different molecule-induced doping in the two cases (Fig. 8d).

The same Au/AZO-SAM/MoS$_2$ stack was exploited to demonstrate photo-switchable vertical diodes, in which the current flowing vertically through the stack was measured by contacting the MoS$_2$ sheet with a conductive tip in an atomic force microscope (AFM). With the AZO-SAM in the trans state, a rectifying diode-like trace was measured with turn-on voltage close to 0.5 V (Fig. 8e). After photo-isomerization to the cis state, the $I$-$V$ traces showed a
suppression of the rectification, while the diode-like characteristics could be partially recovered by switching back the AZO-SAM to the \textit{trans} state. These experiments demonstrate the possibility to modify reversibly the energetics of TMDs thanks to a unique molecular capability, such as the switching of photochromic molecules. In this regard, hybrid systems composed of functional molecules/TMDs represent an entirely new class of materials characterized by unique properties different from those of the isolated components even in the absence of covalent bonds.

**Physisorbed crystalline monolayers on TMDs.** While in the previous section we have discussed the case of molecular tailoring of the \textit{bottom} TMD surface, here we focus on the effect of non-covalent molecular modification of the \textit{top} TMD surface. Supramolecular interactions, in particular of van der Waals type, can drive the formation of physisorbed crystalline monolayers of molecules onto TMDs, in which the molecular dipoles self-align,\textsuperscript{81, 252, 253} thereby giving rise to electrostatic effects analogous to those discussed in the previous section. This possibility was demonstrated by the works by Kang \textit{et al.},\textsuperscript{39, 86} in which ordered molecular layers were physisorbed onto the top TMD surface to induce non-degenerate doping effects (Fig. 9a). In contrast to the case of TMD onto SAM-modified substrates, in the case of top surface modification it was possible to measure the electrical characteristics of the TMDs before and after the formation of the molecular layer, enabling a precise estimation of the doping introduced by the molecular layer. Interestingly, the molecules investigated for the modification of the top surface of few-layer MoS\textsubscript{2} and WSe\textsubscript{2} (ODTS and APTES, Fig. 9a) bear the same functional groups used for tailoring the bottom substrate via SAM chemisorption (Fig. 8a).\textsuperscript{39, 86} Fig. 9b displays the effect of ultrathin ODTS layer on the electrical characteristics of WSe\textsubscript{2}. In this case, a relatively small shift of the threshold voltage towards more positive values was measured, indicative of \textit{p}-type doping. An analogous \textit{p}-type doping was observed for ODTS onto MoS\textsubscript{2}, while the layer of APTES molecules was
observed to induce $n$-type doping on both WSe$_2$ and MoS$_2$ (Fig. 9c). These results are qualitatively similar to those obtained for the same molecules at the bottom of TMDs, and similarly were explained by considering that the doping effects were mediated by molecular dipoles, which effectively changed the surface energetics.$^86$ In particular, it was proposed that the molecular assemblies on the top and at the bottom are specular, so that the TMD layer is effectively affected by analogous electric fields.

We would like to point out that the molecular dipoles orientation is dictated by the molecular arrangement. The fact that analogous doping effects are measured also on different TMDs (MoS$_2$ and WSe$_2$, Fig. 9c) indicates that the arrangement of a given molecule on the sub-nanometre scale on different vdW surfaces is the same. Indeed, analogous van der Waals forces drive the formation of the same assembly on the inert, chemically similar van der Waals surfaces of layered materials.$^{252,253}$ Therefore, one can assume that the doping induced by the assembly of the same molecule on different TMDs is analogous, since the assembly is typically the same.$^{252}$

We mention that the presence of a molecular film on the surface of TMDs can be exploited not only to modify the properties of TMDs at a fundamental level, but also to enable technologically relevant application. As an example, in the work discussed in Fig. 9a-c, it was found that the molecules improved the photoresponsivity and detectivity of TMD-based photodetectors.$^{39}$ Moreover, highly ordered molecular monolayers adsorbed either above or below TMDs have been employed in combination with ultrathin inorganic layers as ultrathin gate dielectrics for flexible electronics.$^{91,254}$ The resulting transistors operating at low voltage showed remarkable subthreshold swing ($< 80$ mV/dec), limited hysteresis and high breakdown field.
3. Chemical treatments for optimizing optical processes in 2D TMDs

The modifications in the optical properties of TMDs discussed in Section 2 arise from changes in the charge-carrier density induced by molecular layers. Here, we discuss a few recent experiments showing how appropriate chemical treatments can be used to optimize the photoluminescence (PL) emission in 2D TMDs in a way that cannot be explained by electronic doping, and which involves the passivation of surface defects.

Typically, the doping-induced PL modulation is relatively weak for monolayer MoS$_2$, with $p$-dopants introducing up to a three-fold PL increase. In contrast, Amani et al. reported on a two-orders-of-magnitude increase in the PL of chemically-treated MoS$_2$, reaching near-unity quantum yield. In particular, the authors demonstrated that a treatment with the nonoxidizing organic superacid bis(trifluoromethane)-sulfonimide (TFSI, inset in Fig. 10a) determined an up-to-190-fold increase in the PL intensity without significant changes in the spectral shape (Fig. 10a). PL maps of the same 2D MoS$_2$ sheet measured before and after the superacid treatment revealed that the increase was spatially homogeneous (Fig. 10b). Remarkably, it was found that at low excitation intensity ($<10^{-2}$ Wcm$^{-2}$), the PL quantum yield approached ~1, i.e. almost the totality of the incoming photons were re-emitted (Fig. 10c). Following the discussion in Section 2, one might expect the PL boost to be mediated by $p$-doping, since TFSI is a strong electron acceptor. Through the comparative electrical characterization of a 2D-MoS$_2$ FET before and after the superacid treatment, the authors demonstrated that TFSI would not induce significant $p$-type doping. Instead, the passivation of surface defects was put forward as main effect leading to the increased PL. Indeed, the low PL quantum yield of (untreated) MoS$_2$ at low excitation power is typically attributed to defect mediated non-radiative recombination; hence the near-unity quantum yield of the treated samples indicates a defect passivation. However, the exact mechanism through which defects are passivated is not entirely understood. More recent studies have shown that the
same superacid treatment could be successfully applied to CVD-grown MoS$_2$,\textsuperscript{98} and that its effect could be made stable by encapsulation with a CYTOP film.\textsuperscript{257} Moreover, it was demonstrated that not only the PL of MoS$_2$ but also that of WS$_2$ is boosted by the TSFI treatment.\textsuperscript{96} On the contrary, the TSFI treatment does not enhance the quantum yield of Se-based TMDs, such as WSe$_2$ and MoSe$_2$.\textsuperscript{96} An STM investigation of the defects in sulfide- and selenide-based TMDs suggested that the different effects of the TSFI treatment could be explained by the distinct nature of the defects in TMD selenides and sulfides.\textsuperscript{96} In particular, the defects found on sulfide surfaces were either structural defects or acceptor impurities, whereas those found on selenide surfaces were mainly donor impurities.\textsuperscript{96} Similarly to the case of TFSI, an acid-mediated sulfur vacancies self-healing was put forward in a recent experiment in which MoS$_2$ was placed in contact with non-oxidizing acid poly(4-styrenesulfonate) (PSS).\textsuperscript{258} In this case, self-healing was accompanied by a $p$-type doping effect and a rather limited PL increase (two-fold).

A similar acid based self-healing of defects was demonstrated for Se-based TMDs. In particular, it was demonstrated that the PL of CVD-grown MoSe$_2$ could be increased via treatment with hydracids.\textsuperscript{100} The highest effect was found for hydrohalic acid (HBr), which caused a 30-fold increase in the PL of MoSe$_2$ (see Fig. 10d-e). In this case, two concomitant mechanisms were identified to account for the measured effect: (i) an induced $p$-type doping, as inferred from a Raman characterization and (ii) an acid-mediated structural healing, inferred on the basis of low temperature PL spectra and XPS characterization. In particular, for untreated MoSe$_2$ sheets, the PL spectrum was dominated by a rather broad PL peak at $\sim$1.56 eV, which was ascribed to the radiative emission of excitons bound to defects (Fig. 10f). Instead, after HBr treatment, the low temperature PL became more structured, with two sharper peaks corresponding to the neutral exciton and trion peak. The decrease in the relative intensity of the defect-related peak indicated the HBr-induced defect healing in MoSe$_2$. In
particular, the authors found spectroscopic evidences of undesired oxidized Se in the as-
grown CVD MoSe$_2$, and concluded that HBr effectively passivates these defects by replacing
oxidized Se defects (Se-O) with Br, which covalently binds to Mo atoms.$^{100}$
These experiments indicate the potential of acid treatments to passivate defect-mediated
recombination pathways in TMDs, leading to almost-ideal optical properties. Therefore, the
chemically treated ultrathin TMDs might enable the demonstration of optimized
optoelectronic devices, such as high-performance light-emitting diodes, lasers and solar cells.

4. Covalent functionalization via defect and phase engineering

During the last five years, several works have been published on the covalent
functionalization of ultrathin TMDs, mainly focusing on solution-processed MoS$_2$ nanosheets
produced via ion intercalation (1T/1T$'$ phase)$^{259,260}$ or ultrasonication (1H/2H) methods.$^{110,261}$
These studies will be presented in Section 5, which is dedicated to solution-based approaches
for the preparation of inks of functionalized TMDs. Here, we will review those investigations
carried out on substrate-supported nanosheets, which aimed at “decorating” the top surface of
the 2D materials with molecules through bond-formation processes. As mentioned in the
introduction, MoS$_2$ is the prototypical element of the TMD class,$^{19}$ so that pioneering
explorations in this research area have been carried out mostly on this promising 2D
semiconductor. However, the concepts and strategies described in the following can be easily
extended to other ultrathin TMDs, in particular MoWSeS materials, which have structural and
physico-chemical properties similar to those of MoS$_2$. Indeed, all MoWSeS crystals exhibit a
stable 1H/2H semiconducting phase$^{9,150}$ and their surface lacks dangling bonds, a fact that
makes the covalent functionalization of the basal plane a challenging objective.$^{80,110,200,260}$
In 2014, Azcatl et al.$^{262}$ reported on a non-disruptive method for the functionalization of
MoS$_2$ based on exposure to UV-ozone. The latter induces the formation of an oxygen layer on
the surface of the 2D semiconductor, which can be conveniently exploited as a seed layer for the growth of high-quality dielectric films by atomic layer deposition (ALD).\textsuperscript{262, 263} Noticeably, the structural and the electronic properties of MoS\textsubscript{2} were not found to be altered by the UV-ozone treatment, which supported the finding of weak bonding interactions between oxygen and sulfur atoms.\textsuperscript{262, 263}

Nowadays, two major strategies are being explored towards the strong covalent or coordinative bonds between TMDs and atomic or molecular adlayers. The first involves the activation/optimization of the chemical reactivity of the nanosheets’ surface via the controlled generation of point defects, such as chalcogen vacancies. In such a way, dangling bonds are generated locally at defect sites, enabling the formation of chemical bonds between the defective surface and molecules with \textit{ad hoc} functional groups. The second method deals with the phase tunability of TMDs,\textsuperscript{135} which allows for the reversible conversion of the electron-rich and easy-to-functionalize polytype (1T/1T\textsuperscript{′}) into the more inert semiconducting polytype (1H/2H).\textsuperscript{80} As we shall see, the latter approach enables preparing functionalized 1H/2H nanosheets through phase-conversion processes triggered by chemical or thermal stimuli.\textsuperscript{80}

4.1 Engineering chemically-active defects

Numerous techniques have been used to engineer defects, such as chalcogen vacancies, in the basal plane of ultrathin TMDs, among which electron irradiation,\textsuperscript{264-267} thermal annealing,\textsuperscript{88} electrochemical generation,\textsuperscript{186} plasma treatments,\textsuperscript{185, 270-273} as well as physical bombardments with charged particles, including ions of argon,\textsuperscript{109, 274-276} helium,\textsuperscript{277-279} manganese,\textsuperscript{280} \textit{α} particles (He\textsuperscript{2+}),\textsuperscript{159} and swift heavy ions (\textit{e.g.} Xe/Ta, \( E \approx 80-100 \text{ MeV} \)).\textsuperscript{281} Moreover, chalcogen vacancies have been systematically generated during the growth/synthesis process via non-equilibrium CVD methods,\textsuperscript{223} as well as through hydrothermal synthetic strategies.\textsuperscript{282} Theoretical calculations have also been carried out to corroborate experimental results and elucidate the structures/properties of the defects.
produced with such techniques, *e.g.* in the case of electron irradiation (refs 68, 267) and ion bombardment (ref. 283). In 2012, Komsa *et al.* carried out a joint theoretical and experimental investigation on the effects of electron irradiation on the atomic structure of ultrathin TMDs. In particular, they observed the formation of sulfur vacancies (SV) in 1H-MoS$_2$ sheets exposed to an electron beam ($E \approx 80$ keV) within a high-resolution transmission electron microscope (HRTEM). The possibility of filling the SVs with donor and acceptor impurities — with the objective of introducing doping — was supported by calculations of the formation energy of substitutional defects. Experimentally, *in situ* HR-TEM studies provided evidence for the occurrence of SV filling (see Fig. 11a-c), though it was not possible to identify the type of the impurity involved in the process. Subsequent theoretical works were carried out on substitutional doping of TMDs, and various strategies have been proposed for adding novel functionalities to MoS$_2$ by means of magnetic, rare-earth and chalcogen dopants, as well as molecular ions. More recently, a combined TEM and Raman-spectroscopy study (ref. 265) allowed establishing a correlation between the density of SVs in electron-irradiated MoS$_2$ nanosheets and the energies of the main Raman-active phonon modes ($E_{2g}$ and $A_{1g}$), thereby providing an indirect means for quantifying SVs in ultrathin MoS$_2$.

In 2013, Ma *et al.* showed that low-energy ($E \approx 500$ eV) argon-ion irradiation of monolayer MoS$_2$ results in the controlled generation of SVs, as evidenced by X-ray photoemission spectroscopy (XPS) studies, see Fig. 11d. In contrast to their electron counterpart, ion beams have relatively larger diameters (~100s µm) and can be rastered over centimetre-scale large areas in relatively short time, enabling the fast processing of wafer-scale CVD-grown films. Although this was the first study on a truly 2D semiconductor, it should be mentioned that several investigations have been carried out in the past on the effects of argon ion bombardment on bulk TMD crystals. In 1972, Williams *et al.* performed low-energy ($E \approx 300$ eV) argon-ion bombardment on the surface of various layered chalcogenide...
materials, among which MoS$_2$, NbSe$_2$, ZrS$_2$, MoTe$_2$, TiTe$_2$ and SnS$_2$, revealing — in most of the cases — a significant enhancement of the reactivity of the basal plane in the presence of oxygen species. This was attributed to the pitting and faceting of the surface upon ion bombardment, leading to the increase of the effective surface area of the sample. However, little was known about the structure of the defects. Two years later, Feng and Chen conducted XPS measurements on bulk MoS$_2$ crystals irradiated with argon ions of $\sim$300 eV, and observed the formation of islands of metallic molybdenum along with a decrease in the sulfur content. The authors hypothesized that sulfur atoms, which have a mass similar to that of argon, could be ejected more efficiently in comparison to heavier molybdenum atoms, thereby enabling a selective sputtering process. Nowadays, bombardment with argon-ion beams is a common and established method for engineering chalcogen vacancies in ultrathin TMDs, together with similar techniques based on plasmas of argon ions. In 2016, Li et al. showed — both theoretically and experimentally — that SVs generated via argon plasmas lead to the activation of the basal plane of 1H-MoS$_2$ monolayers for hydrogen evolution reaction (HER), which could be further optimized through the application of in-plane strain. The HER activity of 1H-MoS$_2$ sheets has also been enhanced through electrochemical desulfurization processes (ref. 186), which allowed tuning the density of SVs by changing the applied desulfurization potential. Additionally, complementary thermal approaches have been developed for the generation of SVs, such as annealing in ultra-high vacuum ($p \approx 10^{-9}$ torr, $T \geq 200 \, ^\circ\mathrm{C}$) or in air ($T \approx 250 \, ^\circ\mathrm{C}$).

Having a high density of chemically-active chalcogen vacancies is desired for the purpose of functionalization, but it can also be very detrimental in other perspectives, e.g. for applications in (opto)electronic devices. In a recent work, the effects of ion-beam induced SVs on the optical, vibrational, as well charge transport properties of mechanically-exfoliated monolayer MoS$_2$ have been investigated (ref. 109). The unencapsulated channel of back-gated
monolayer FETs has been irradiated with low-energy \( (E \approx 500 \text{ eV}) \) argon ions, as shown in Fig. 11e. This allowed monitoring the evolution of the electrical characteristic of the devices with increasing ion dose, as shown in Fig. 11f and g. Noticeably, the experiments were carried out under inert atmosphere to minimize possible oxygen chemisorption at defect sites, which could affect the electronic structures/properties of semiconducting TMDs.\(^{292}\) The results reported in this work\(^{109}\) provided a guideline for the trade-off choice between density of SVs suitable for chemical functionalization and device performance, in terms for instance of charge-carrier mobility and \( I_{\text{on}}/I_{\text{off}} \) switching ratio in FETs.

### 4.2 Repair and functionalization of defective TMDs

In the last few years, various research groups have explored the possibility of repairing/functionalizing defective MoS\(_2\) nanosheets with small organic molecules carrying thiol headgroups.\(^{88, 109, 293}\) Noticeably, the reactivity of SVs with thiol molecules has been investigated since the 1970s, mainly due to the widespread use of MoS\(_2\) as a catalyst for hydrodesulfurization to remove sulfur from oil.\(^{294}\) The adsorption and decomposition of alkanethiols on defective MoS\(_2\) surfaces have been previously investigated, for instance in the case of butanethiol,\(^{294}\) ethanethiol,\(^{295}\) methanethiol\(^{296}\) and dodecanethiol.\(^{181}\) In 2012, Makarova et al.\(^{181}\) reported a STM study supporting the hypothesis of bond formation between thiol groups and unsaturated molybdenum atoms at SV sites. In particular, two thiol derivatives — namely (3-mercaptopropyl)-trimethoxysilane (MPS) and dodecanethiol — were adsorbed to the surface of bulk 2H-MoS\(_2\) crystals, as schematized in Fig. 12a. The density of molecules was found to match the typical density of SVs in common MoS\(_2\) samples, suggesting a possible chemisorption of the thiol molecules at SV sites. Interestingly, the authors observed that both thiol derivatives could be easily desorbed from the surface by applying electrical stimuli with the STM tip, a phenomenon that was ascribed to the tip-induced dissociation of the S-C bond (Fig. 12b). Remarkably, such a process was found to
lead to the filling/repairing of the SVs. Inspired by these results, Yu et al.\textsuperscript{182} developed a thiol-chemistry approach with the aim of healing defects and improving the charge-transport properties of ultrathin sheets of MoS\textsubscript{2}. The treatment consists in the immersion of SiO\textsubscript{2}/Si substrates carrying mechanically-exfoliated MoS\textsubscript{2} flakes in a solution of MPS in dichloromethane, followed by thermal annealing ($T \approx 50$ °C, 20 min) to induce the scission of the S-C bond and remove the excess MPS molecules. Density functional theory calculations (DFT) were carried out to assess the kinetics of the reaction, shown in Fig. 12c. The effective reduction of the number of SVs was supported by a statistical analysis of HR-TEM images acquired from as-exfoliated and treated samples, which revealed a decrease in the average SV density from $\sim 6 \times 10^{13}$ cm\textsuperscript{-2} to $\sim 1.6 \times 10^{13}$ cm\textsuperscript{-2}. Thanks to their trimethoxysilane groups that chemisorb on SiO\textsubscript{2}, MPS molecules have also been used for the formation of SAMs on the oxidized silicon substrates. In this case, the molecules expose their thiol groups towards the overlying MoS\textsubscript{2} nanosheets, thereby providing — upon annealing — an opportunity for healing SVs in the bottom surface. The effects of such thiol-chemistry treatments on the electrical properties of back-gated MoS\textsubscript{2} FETs are reported in Fig. 12d and e. Upon repairing SVs in the top and bottom surfaces, the field-effect mobility increases up to $\sim 80$ cm\textsuperscript{2}V\textsuperscript{-1}s\textsuperscript{-1} (at room temperature), which is one of the highest values achieved so far using back-gated monolayer MoS\textsubscript{2} FETs on conventional SiO\textsubscript{2}/Si substrates.\textsuperscript{297} A follow-up work by Cho et al.\textsuperscript{293} focused on the passivation of SVs in multilayer MoS\textsubscript{2} sheets (2-11 nm thick) with alkanethiol molecules. The healing procedure, based on the immersion of the samples into an ethanol solution of hexadecanethiol (or octanethiol) molecules, did not include the annealing step previously used to promote the scission of the S-C bond and the removal of not-chemisorbed molecules. As a result, the electrical current and the charge-carrier mobility in FETs were found to decrease. This was ascribed to trap states associated with alkanethiol molecules chemisorbed at SVs. Sim et al.\textsuperscript{88} adopted a similar approach aiming at introducing a stable
doping in few-layer MoS$_2$ nanosheets (2-4 layer thick) via chemisorption of thiol molecules carrying donor or acceptor groups, see Fig. 12f. After immersing the samples in ethanol solutions of mercaptoethylamine (NH$_2$-terminated thiol, MEA) and 1H,1H,2H,2H-perfluorodecanethiol (CF$_3$-terminated thiol, FDT), the authors performed a mild annealing under inert atmosphere (100 °C, 30 min) and an abundant solvent rinsing to remove unbound molecules. Such a treatment resulted in $n$-doping in the case of MEA ($\Delta n \approx 3.7 \times 10^{12} \text{ cm}^{-2}$) and $p$-doping in the case of FDT ($\Delta n \approx -7.0 \times 10^{11} \text{ cm}^{-2}$), which was supported by multiple techniques, including PL spectroscopy, XPS and electrical measurements. In FETs, the doping effect appeared more evident after an additional annealing step ($T \approx 150$ °C, 10 min) that served for removing water and oxygen molecules that are known to behave as electron acceptors. The resulting transfer characteristics of pristine (black) and doped (red and blue) few-layer MoS$_2$ FETs are shown in Fig. 12g. More recently, short-chain alkanethiols, such as butanethiol, have also been used to heal SVs introduced via low-energy ion irradiation in the channel of monolayer MoS$_2$ FETs (ref. 109). In this case, a vapour-phase deposition process — carried out strictly under inert atmosphere without other external influences — enabled a significant recovery of the electrical characteristics of ion-irradiated FETs, confirming the occurrence of defect healing by thiol molecules.

The results discussed so far showed that repair (involving the dissociation of the S-C bond) and functionalization of SVs via chemisorption of thiols are two possible outcomes. This aspect has been investigated theoretically by two groups,$^{183,184}$ who showed by means of DFT calculations that both reactions can actually occur. Nevertheless, the mechanisms involved might vary depending not only temperature but also on polarization effects associated with the molecule’s decorating groups.$^{183}$ In the case of methanethiol, Förster et al.$^{184}$ found that repair is energetically most favourable over functionalization, whereas Li et al.$^{183}$ concluded that functionalization products are preferred due to slightly smaller energy barriers. However, it
should be noticed that such discrepancies may arise from different assumptions on the role of hydrogen in the reaction (adsorption/release), which is a debated argument in the chemistry of thiols at metal surfaces.\textsuperscript{244, 299-303} At this stage, more investigations are needed to identify the exact experimental conditions leading to the repair or functionalization of SVs.

The methods discussed above can be extended to other elements of the TMD family, in particular MoWSeS materials. For instance, the generation, healing and doping functionalization of selenium vacancies in ultrathin WSe\textsubscript{2} have been already reported in the last years.\textsuperscript{79, 271, 304} It is expected that 2D transition metal selenides could be similarly functionalized/repaired with molecules carrying selenol headgroups,\textsuperscript{305} or once again repaired with thiol molecules — since sulfur and selenium are valence-isoelectronic elements — and this would allow developing 2D nanosheets with tunable chalcogen composition (e.g. WS\textsubscript{2-x}Se\textsubscript{2(1-x)}).\textsuperscript{306} Despite problems associated to the limited chemical stability of selenol exposing molecules, novel investigations can be foreseen to explore the viability of these approaches.

4.3 Covalent functionalization via phase engineering

An alternative strategy for the covalent functionalization of ultrathin MoS\textsubscript{2} was reported in 2015 by Chhowalla and coworkers.\textsuperscript{80} Such a method does not involve chemical reactions at defects, as previously discussed, but it rather exploits the phase tunability of TMDs\textsuperscript{135} via chemical and thermal stimuli. It is known that chemical exfoliation with \textit{n}-butyllithium leads to electron-rich nanosheets that contain \(~65\%\) of the metallic 1T/1T' polytype.\textsuperscript{141, 142} Interestingly, also the exposure of substrate-supported CVD MoS\textsubscript{2} sheets to \textit{n}-butyllithium results in the change from the 1H to the 1T/1T' phase, as illustrated in Fig. 13b. This procedure was later shown to be also applicable to continuous polycrystalline MoX\textsubscript{2} films.\textsuperscript{307} This can be performed in a spatially-controlled manner, which is suitable for patterning metallic regions in a semiconducting 2D layer to develop low-resistance contacts for ultrathin
MoS\textsubscript{2} FETs.\textsuperscript{308} Chhowalla \textit{et al}.\textsuperscript{80} showed that metallic 1T/1T′ nanosheets can be easily functionalized by subjecting them to methyl iodide and iodoacetamide electrophiles (see Fig. 13a), resulting in functional groups that are covalently bound to sulfur atoms. Here, the reaction is promoted by charge transfer between the electron-rich 1T/1T′ MoS\textsubscript{2} and the organohalides, which allows for achieving a degree of functionalization of the order of ~30% (estimated by XPS). Atomic-resolution TEM studies carried out on functionalized nanosheets revealed that the original atomic structure with octahedral coordination is not altered by such a process (Fig. 13c). However, the functionalized 2D MoS\textsubscript{2} displayed optical properties remarkably different from those of its not-functionalized counterpart, including fluorescence emission (Fig. 13d). The latter indicates the opening of a semiconducting bandgap, which is a promising result proving the possibility of tailoring ultrathin TMDs by the combination of chemical and phase-engineering approaches.

The authors further showed that CVD monolayer MoS\textsubscript{2} films can be converted from 1H to 1T/1T′ via n-butyllithium exposure; they can then be functionalized with electrophile molecules and subsequently re-converted into the 1H polytype by thermal annealing at \(T \geq 300\) °C. Raman and XPS spectroscopy confirmed the occurrence of the semiconducting-phase recovery, whereas attenuated total reflectance Fourier transform infrared (ATR-FTIR) spectroscopy indicated that functional groups were still present on the surface of the 1H MoS\textsubscript{2} sheets. This technique — based on a two-step phase conversion process — is being regarded as a promising strategy for the covalent functionalization of semiconducting MoWSeS materials, which otherwise could not be functionalized in their pristine form due to the lack of dangling bonds. It is worth noting that the methods described above were applied also to WS\textsubscript{2} and MoSe\textsubscript{2}, and are expected to be applicable to other TMDs.\textsuperscript{76,80} In this research area, additional investigations are envisioned for tuning of the optical and electronic properties of ultrathin...
TMDs ad hoc for applications, which can be achieved for instance by a careful choice/design of the electrophile molecules.

5. Functionalization of solution-processed TMD nanosheets

Functionalization can also be achieved on TMD nanosheets in the liquid phase by a number of strategies. The prerequisite is an efficient exfoliation in liquid to obtain colloidally stable dispersions. For TMDs, two main strategies exist which are referred to as chemical exfoliation (CE) and liquid phase exfoliation (LPE), respectively. Chemical exfoliation is based on the intercalation chemistry of TMDs first described in the 1970s.\textsuperscript{117, 309} Based on these early reports, the intercalation chemistry was explored in detail in the past century.\textsuperscript{310} The current understanding of the chemical exfoliation is described in detail elsewhere\textsuperscript{15, 115} and is only briefly summarized here. The most commonly used technique is based on the reaction of bulk TMD powder with $n$-BuLi under inert conditions. Lithium is inserted between the layers followed by an electron transfer to the TMD resulting in an Li$_x$MX$_2$ salt. Due to the Coulomb repulsion between the negatively charged layers, efficient exfoliation down to predominantly monolayers can be achieved after agitation/sonication in water. After purification (removal of excess $n$-BuLi, reaction side products, unexfoliated TMD), a colloidal suspension of negatively charged nanosheets in water is obtained. Due to the excess charge, the MoWSeS-TMDs undergo a transition from the semiconducting 2H polytype (trigonal prismatic arrangement of chalcogen) to the metallic 1T/1T$'$ polytype (octahedral arrangement of chalcogen, often distorted)\textsuperscript{115} — see Section 1.1. The metallic 1T-polytype is metastable and can be converted to the 2H-polytype on annealing or by ageing which is usually accomplished by flocculation of the TMDs if this takes place in the dispersion. Depending on the reaction conditions,\textsuperscript{260, 311, 312} defective nanosheets (chalcogen vacancies and/or holes on the basal plane) or mixtures of the 1T/2H-polytype are accessible.
A complementary technique that yields colloidally stable dispersions of group VI-TMDs in the semiconducting 2H-polytype is liquid phase exfoliation (LPE). As summarized in detail in recent reviews,\textsuperscript{106, 313-317} this process involves sonication (or other forms of agitation such as shearing, ball milling) of the bulk powder in appropriate solvents or aqueous surfactant systems. A range of polymers (including biopolymers) can also be used as stabilizing agents in both aqueous and organic media. The energy or mechanical stress is required to overcome the van der Waals-type intersheet interaction and causes exfoliation of the bulk material into few-layers in the liquid with the nanosheet reaggregation prevented by the solvent/stabilizer. This process has first been demonstrated in 1989 \textit{via} sonication of TMDs in water in an argon-hydrogen atmosphere.\textsuperscript{318} However, in ambient conditions, water as a neat solvent (\textit{i.e.} without additional stabilizers) is not a suitable solvent to stabilize the TMD nanosheets. It was first demonstrated by Coleman \textit{et al.} in 2011,\textsuperscript{122} that solvents with solubility parameters matching the TMD can be used to obtain colloidally stable dispersions under ambient conditions. Suitable solubility parameters to describe the solution thermodynamics are solvent surface tension or energy, Hildebrandt parameters or Hansen parameters. Typical solvent choices are N-methyl-2-pyrrolidone, N-cyclohexyl-2-pyrrolidone, dimethyl formamide or isopropanol to a lesser extent. Alternatively, as first demonstrated by the same group,\textsuperscript{319} aqueous surfactant solutions can be used. The resultant nanosheet dispersion are highly polydisperse with respect to both layer number and lateral size, but size selection techniques have been developed to tackle this problem.\textsuperscript{320}

Based on such nanosheet dispersions, numerous strategies have been developed to functionalize both basal plane and edges (Fig. 14). Due to the high surface area of the nanosheets, non-covalent functionalization \textit{via} physisorption of various molecules, polymers (or noble metal nanoparticles) is commonly exploited. Note that numerous hybrid structures with other nanomaterials can be constructed in such a way as outlined elsewhere.\textsuperscript{321} The most
widespread use of this non-covalent approach is to prevent nanosheets from reaggregation after LPE by adsorption of small molecules\textsuperscript{105, 319, 322-332} or (bio)polymers\textsuperscript{333-361} (see Table 2). The organic functional groups are believed to adsorb to the nanosheets \textit{via} predominantly van der Waals interaction and dipole interactions can also occur\textsuperscript{203, 362}.

Similar to graphene, stabilization in the aqueous environment in the case of ionic surfactants is achieved mostly due to Coulomb repulsion that can be described within the Derjaguin-Landau-Verwey-Overbeek (DLVO) theory, even though steric hindrance can also play an important role\textsuperscript{363}. Unfortunately, it is extremely challenging to unravel experimentally how the surfactant adsorption occurs, or indeed how densely the surfactant is packed on the surface. Ref. 326 is highlighted in this regard, as it provides evidence that surfactant chains of the cationic amphiphile cetyltrimethylammonium bromide (CTAB) and the anionic surfactant sodium dodecyl sulfate (SDS) lie flat, arranged randomly on the basal plane of the MoS\textsubscript{2} nanosheets with their charged headgroup exposed. It was also shown that they exchange rapidly with free surfactants in the surrounding water. One of the most widely used classes of surfactants are facial amphiphiles such as sodium cholate (SC)\textsuperscript{105, 319, 324, 327-329, 331}. As demonstrated in the original work\textsuperscript{319}, such surfactant-based dispersions can be used to fabricate thin films or nanocomposites \textit{(e.g.} by vacuum filtration) which can for example be used as electrodes in electrochemical water splitting\textsuperscript{364, 365}. However, as shown recently, SC can have detrimental effects for electrocatalysis\textsuperscript{366} which emphasizes that more research is required to explore strategies to remove physisorbed molecules/polymers after processing for certain applications.

In the case of non-ionic surfactants\textsuperscript{332} or polymers\textsuperscript{333-345} stabilization is due to steric effects that can be described in the framework of solution thermodynamics\textsuperscript{334}. In general, poloxamers \textit{(e.g.} Pluronics)\textsuperscript{335, 339, 341, 344, 345, 367} are the most widely studied polymeric stabilizers. In particular Pluronic F68 has been used to decrease the buoyant density of the nanosheet-
polymer hybrid in water to allow for thickness sorting in a density gradient. Among the various structural characteristics, the thickness of the TMD sheets is known to define their properties; hence, the use of efficient layer number separation techniques is important. However, the yields of this process are currently low due to a low monolayer yield in the initial dispersion. This encouraged the authors to screen 19 different poloxamers with respect to their exfoliation efficiency (dispersed nanosheet concentration and monolayer content). Nevertheless, as outlined in ref. 335, the presence of polymers during the exfoliation can result in poorer exfoliation compared to solvent or small molecule-assisted LPE in terms of mean layer number and lower dispersed concentration, as the surface tension of the liquid increases with the polymer concentration. The authors suggested to add the polymer stepwisely during the exfoliation to overcome this.

In addition, a range of natural polymers/oligomers have been exploited in the non-covalent functionalization as summarized in Table 2. These are typically used to obtain biocompatible TMDs for biomedical and biosensing applications. Popular examples include chitosan, bovine serum albumin or oligonucleotide sequences. The interaction with the TMDs can be considered as predominantly van der Waals-type, while the stabilization is based on both Coulomb and steric repulsion.

Another non-covalent functionalization strategy is based on the electrostatic interaction of cationic molecules with negatively charged 1T-TMDs. Such colloids are more stable than the 1T-MX$_2$ in water on its own or can be used for a solvent exchange to organic media. Stabilization with oleylamine in high boiling point solvents such as octadecene or o-dichlorobenzene allows the conversion of 1T-MX$_2$ to 2H-MX$_2$ in the dispersions by heating without causing flocculation.

Even though the basal plane of TMDs is widely considered inert, a number of functionalization strategies via chemisorption have been developed. As illustrated in Fig. 14,
these can be classified as (i) covalent (ii) coordinative, (iii) defect or (iv) coordinative defect functionalization. Note that not all strategies are accessible from both 1T-CE-MX\(_2\) and 2H-LPE-MX\(_2\) or lead to a different result with respect to the degree of functionalization (number of functional groups per MX\(_2\)) or type of binding as illustrated in Fig. 15 and summarized in Table 2-6.

Covalent modification refers to a reductive functionalization of negatively charged 1T-CE-MX\(_2\) with electrophiles and involves the formation of a carbon-chalcogen bond on the basal plane.\(^{78, 80, 196, 260, 372-374}\) In the first report by Voiry et al.,\(^{80}\) CE-1T-MoS\(_2\)-WS\(_2\) and –MoSe\(_2\) was reacted with alkyl halides (or an aryl diazonium salt). Similar to the first covalent functionalization of graphene,\(^{375}\) the electrophile attacks the negatively charged nanosheets. On charge neutralization, a covalent carbon-chalcogen bond is formed on the basal plane with degrees of functionalization of 20% (with respect to functional groups per MX\(_2\) unit). The successful functionalization was evidenced by \(^{13}\)C-NMR spectroscopy, IR spectroscopy and X-ray photoemission spectroscopy (XPS). XPS spectra of functionalized 1T-MoS\(_2\) (Fig. 16a) show evidence for a S-C in the S core level spectra in addition to the characteristic features of 1T, and 2H-MoS\(_2\). The chalcogen-carbon bond is further observed in the IR spectra (Fig. 16b) in addition to the alkyl vibrations of the functional group. Importantly, the peak frequency shifts depending on the chalcogen as would be expected. The 1T-polytype is retained, but exhibits semiconducting properties after covalent functionalization due to the charge neutralization.

In a subsequent work, the question was addressed whether defects often present on CE-1T-MX\(_2\) are required for successful functionalization.\(^{260}\) This was achieved by intercalating MoS\(_2\) with excess MoS\(_2\) over \(n\)-BuLi. Compared to the traditional intercalation that uses excess \(n\)-BuLi, a significant portion of the MX\(_2\) (~50%) remains in its 2H-polytype as confirmed by XPS (Fig. 16c, d) and thermogravimetric analysis (TGA) revealed that the nanosheets are less
defective (Fig. 16e). Covalent functionalization of CE-2H/1T-MoS$_2$ with an aryldiazonium salt was evidenced (by XPS, IR spectroscopy and TGA coupled to mass spectrometry), albeit with lower degrees of functionalization (~10% per MoS$_2$ unit). In spite of this lower degree of functionalization, it is clear that defects or the 1T-polytype are not a prerequisite for the reductive functionalization and it will be possible to tailor the degree of surface decoration via the amount of charges initially present on the CE-MX$_2$. The 1T-polytype was found to convert rapidly (within a few days) into the 2H-polytype in the case of the CE-2H/1T-MoS$_2$ from intercalation using excess MoS$_2$. However, it is stabilized after functionalization. In analogy to the work by Voiry et al.,$^{80}$ it was suggested that it exhibits semiconducting properties. This covalent functionalization has subsequently been used to anchor various organic functionalities,$^{78,372-374}$ or to graft molecules on the TMD surface that can be used as ligands for further derivatization via coordination chemistry.$^{373,374}$ This approach is particularly interesting for catalytic applications. In a recent study, it has also been shown that 4-carboxy benzene diazonium salt can be reacted with edges of LPE-2H-MoS$_2$ in the presence of an amine catalyst.$^{196}$ Cross-linking of the edges in a network via hydrogen bonding provided the proof of concept that such edge functionalization sequences can play an important role in (opto)electronics in the future, as the authors observe a drastically increased charge-carrier mobility in the network. It is worth noting that despite MoS$_2$ nanosheets are known to behave as unipolar $n$-type semiconductors, the authors reported an unusual unipolar $p$-type transport, whose origin cannot be easily rationalized.

Alternatively, the basal plane of 2H-LPE-TMDs can be decorated by cationic metal complexes using the TMD chalcogens as ligands in a Lewis acid-base type of coordination chemistry.$^{110,376}$ This strategy builds on the work of Tremel et al on MoS$_2$-fullerenes$^{377}$ and has recently been adapted for the functionalization of InSe.$^{378}$ In particular Cu$^{2+}$ ions were identified as suitable anchors to the TMD chalcogens (as evidenced by IR spectroscopy and
This strategy is interesting, as it is a rare example of the chemical basal plane functionalization of the semiconducting 2H-polytype which is retained after the functionalization. However, it remains little explored and further work will be required to demonstrate its versatility as well as possibilities of further derivatization.

The most commonly used chemisorption strategy exploits chalcogen vacancy defects to coordinate nucleophiles in dative bonds, in particular thiols with dithiolane used to a lesser extent. This functionalization concept often referred to as ligand conjugation was first introduced by Dravid and coworkers in 2013, where CE-1T-MoS$_2$ was reacted with a number of thiol-terminated polyethylene glycol derivatives bearing different ionic and non-ionic headgroups. This leads to a tuneable and pH-stable colloidal stability (Fig. 16g top). Zeta potential measurements suggest the successful decoration of the nanosheet surface, as the zeta potential could be tuned from $\sim$60-40 mV depending on the functional group. The disappearance of SH vibrations in the IR spectra indicate that thiols are deprotonated and the S bound to the MoS$_2$. In this strategy, CE-1T-MoS$_2$ is typically used, as it exhibits a higher density of sulfur vacancies than LPE-2H-MX$_2$ unless they are introduced on purpose. However, as discussed in Sections 1.1 and 4.1, such defect sites (amongst others) are also observed in micromechanically-cleaved or CVD-grown monolayers, so that this strategy is not restricted to liquid-suspended nanosheets. In the case of LPE-2H-MX$_2$, edge functionalization is believed to be more favourable, for example by coordinating polyacrylic acid or dithiolane derivatives to metal-rich edges and thionine or polybutadiene to sulfur-rich edges, respectively. Note that in the latter two cases, the ligand serves as an electron acceptor in the coordinative bond.

In some cases, thiol coordination to the basal plane of LPE-2H-MoS$_2$ has been suggested, but no unambiguous proof (for example by the emergence of new species in the sulfur core level spectra in XPS) has been provided. Frequently, the disappearance of the S-H vibrations...
in IR spectroscopy (for example Fig. 16g) serves as indicator for the successful defect functionalization. However, as demonstrated by McDonald and coworkers,\textsuperscript{261} this can be due to a TMD-mediated dimerization of thiols to disulfides. In their work, the authors\textsuperscript{261} added cysteine to LPE-2H-MoS$_2$ in isopropanol and observed a dimerization to cysteine and subsequent physisorption rather than a coordination of the thiol to the MoS$_2$. This was a puzzling observation, in particular because no thiol coordination could be evidenced in the reference experiment using CE-1T-MoS$_2$. DFT calculations by Li et al.\textsuperscript{183} suggest that such a SV-mediated dimerization can be a thermodynamically favourable process. In their reaction pathway, a MoS$_2$ SV-mediated homolytic bond cleavage of the S-H is suggested as the first step which then leads to functionalized MoS$_2$ in an exothermic reaction prior to a potential dimerization. However, the activation energy for the dimerization was found to be high (91.5 kJ/mol) — unless free radicals are present — which does not properly account for the observation by McDonald and coworkers.

A recent theoretical work by Förster et al.\textsuperscript{184} provides an alternative explanation to the question why sometimes defect functionalization occurs and sometimes dimerization of the thiol to disulfides. Their DFT calculations revealed that, depending on the nature of defects, an addition of a thiol results in either defect healing, coordination of the sulfur bearing ligand, or formation of disulfides/hydrodisulfides. For example, if sulfur vacancies are present, the thiol can coordinate to the exposed Mo \textit{via} a transition state in an endothermic reaction, where the S-H bond is broken and the sulfur terminated molecule adsorbs to the exposed molybdenum and the hydrogen binds to a neighbouring sulfur atom on the MoS$_2$. This is followed by either vacancy healing or chemisorption of the functional group \textit{via} the sulfur (accompanied with the release of hydrogen) in exothermic reactions. Based on the energetics, the vacancy healing should be favourable. However, if sulfur adatoms are present, the formation of a disulfide can occur in an exothermic reaction \textit{via} a hydrodisulfide (net energy
release of ca. -1 eV) resulting in the formation of a disulfide and structurally perfect MoS$_2$ (adatom healing) accompanied by the release of H$_2$S, albeit with a high activation energy of ~3 eV. Energetics are more favourable if the hydrodisulfide interacts with a nearby sulfur vacancy. This theoretical work is an excellent foundation to explain the different experimental observations. For example, the work by Jeong et al.$^{194}$ showed via XPS that lipoic acid coordinates to LPE-2H-MoS$_2$ via the dithiolane group. This is in contrast to the above mentioned work by McDonald and coworkers, where no coordination (of neither disulfide nor thiol) was observed.$^{261}$ In both cases, LPE-2H-MoS$_2$ was used. However, the protocol differed in a significant aspect: in the case of the work by Jeong et al.,$^{194}$ the reagent lipoic acid was used directly as surfactant and was thus present during the LPE by sonication, while in the case of the study by McDonald and coworkers,$^{261}$ the reagent cysteine was added after the exfoliation in IPA was performed. Since theoretical work has shown that oxidation of MoS$_2$ can readily occur on both the sulfur vacant basal plane,$^{392}$ as well as edge,$^{393}$ the coordination of the sulfur species can potentially be prevented in ambient conditions, if oxidation occurs prior to functionalization. Furthermore, it should be noted that chalcogen and vacancy defects are not the only defects that can be present. For example, numerous antisite defects have also been observed experimentally.$^{164}$ To fully exploit defect functionalization in TMDs, it will therefore be crucial to control both type and content of defects and systematically study their impact on the respective functionalization.

The chemistry of liquid-suspended TMDs can furthermore be exploited to decorate the nanosheets with noble metal (Au, Pt, Ag, Pd) nanoparticles (NPs). These structures are particularly interesting for catalysis, plasmonics or sensing.$^{337, 394-408}$ The growth of can be achieved via non-covalently or covalently bound organic surface functionalities$^{372, 383, 400, 401, 403}$ nicely illustrating that TMD functionalization can be used to create hybrid structures. Alternatively, NPs can be grown directly on both CE-1T-MX$_2$ and LPE-2H-MX$_2$ nanosheets
after reduction of noble metal precursor salts. Typically, an additional reducing agent is added, even though the spontaneous formation (i.e. without additional reducing agent) has also been observed in some cases. This is documented to be the case when CE-1T-MoS$_2$ or CE-1T-WS$_2$ are used. In such a way, a number of noble metal nanoparticles like Pd, Pt or Au can be epitaxially grown on the 1T-MX$_2$ surface. Typical TEM images are shown in Fig. 17a-c. Notably, decoration occurs on the basal plane and XPS (for Au-decorated nanosheets in Fig. 17d) does not show evidence for a covalent binding. This is likely because the excess charges of the CE-MX$_2$ can reduce the metal precursor salt resulting in the nucleation of physisorbed nanoparticles on both basal plane and edge. (Note that the non-covalent binding has not been unambiguously confirmed in all reports).

In contrast to these reports on CE-1T-MoX$_2$, a covalent bond formation between the sulfur of the TMD and AuNPs was demonstrated according to XPS (Fig. 17e) in hybrid materials obtained after reaction of HAuCl$_4$ with LPE-2H-WS$_2$ in the absence of additional reducing agents. In this case, the NPs are predominantly located at nanosheet edges and terraces of incompletely exfoliated nanosheets (Fig. 17f). It was suggested that thiol functionalities present on edges and defect sites act as reducing agent for the initial nucleation resulting in a conversion to disulfides, as indirectly confirmed by an increased electrocatalytic activity in the hydrogen evolution reaction, where disulfides are the predominant active sites. Due to the higher mass of Au-decorated WS$_2$ opposed to the native WS$_2$ in combination with the edge decoration, an enrichment of monolayers was readily achieved by centrifugation resulting in WS$_2$ dispersions with monolayer volume fractions of 50-90% (depending on the initial lateral size of the LPE-WS$_2$) with a sparse decoration of nanoparticles around the edges (Fig. 17g). The optical properties of the semiconducting 2H-polytype (e.g. photoluminescence
of monolayers) were retained making these hybrids potentially interesting for printed optoelectronics.

By and large, the (multi)functional inks developed by combining TMDs with suitably designed molecules can express unique functionalities which are resulting from those determined by the individual components. Their processing and integration for device applications (e.g. in opto-electronics, photonics, sensing, etc.) can be carried out using up-scalable methods such as printing (ink-jet, roll-to-roll, etc.) and spray-coating, and the devices can be easily supported on flexible foils, opening new intriguing perspectives in the fields of flexible, foldable and wearable (opto)electronics.
Table 2. Functionalization of solution-processed group-6 TMD nanosheets via physisorption of molecules, polymers and biopolymers.

<table>
<thead>
<tr>
<th>Ref.</th>
<th>Interaction</th>
<th>Molecule or (bio)polymers</th>
<th>2D material</th>
<th>Exfoliation Method</th>
<th>Medium</th>
<th>Reason for functionalization</th>
</tr>
</thead>
<tbody>
<tr>
<td>319</td>
<td>van der Waals</td>
<td>sodium cholate (SC)</td>
<td>2H-MoS$_2$</td>
<td>sonication</td>
<td>aqueous</td>
<td>stabilization in LPE</td>
</tr>
<tr>
<td>322</td>
<td>van der Waals</td>
<td>$p$-phosphonic acid calix[8]arene</td>
<td>2H-MoS$_2$, 2H-WS$_2$</td>
<td>sonication</td>
<td>aqueous</td>
<td>stabilization in LPE</td>
</tr>
<tr>
<td>323</td>
<td>van der Waals</td>
<td>sodium dodecyl sulfate (SDS)</td>
<td>2H-MoS$_2$</td>
<td>ball milling</td>
<td>aqueous</td>
<td>stabilization in LPE, gas sensing</td>
</tr>
<tr>
<td>369</td>
<td>electrostatic</td>
<td>hexadecyltrimethylammonium chloride (CTAC)</td>
<td>1T-MoS$_2$</td>
<td>CE $n$-BuLi</td>
<td>aqueous</td>
<td>stabilization after chemical exfoliation</td>
</tr>
<tr>
<td>325</td>
<td>van der Waals</td>
<td>alkyl-trichlorosilanes</td>
<td>2H-MoS$_2$</td>
<td>sonication</td>
<td>1,2 dichlorobenzene</td>
<td>stabilization after LPE, thin film formation</td>
</tr>
<tr>
<td>370</td>
<td>electrostatic</td>
<td>cetyltrimethylammonium bromide (CTAB), chitosan (CS)</td>
<td>1T-MoS$_2$</td>
<td>CE $n$-BuLi (hydrothermal)</td>
<td>aqueous, then redispersion in dimethylformamide</td>
<td>transfer to organic solvent; polymer composites</td>
</tr>
<tr>
<td>324</td>
<td>van der Waals</td>
<td>sodium cholate (SC)</td>
<td>2H-MoS$_2$, 2H-WS$_2$</td>
<td>sonication</td>
<td>aqueous</td>
<td>stabilization in LPE for size selection</td>
</tr>
<tr>
<td>371</td>
<td>electrostatic</td>
<td>oleylamine</td>
<td>1T-MoS$_2$</td>
<td>CE $n$-BuLi</td>
<td>aqueous</td>
<td>phase transfer to organic solvents; conversion to 2H-MoS$_2$ in high boiling point solvent</td>
</tr>
<tr>
<td>326</td>
<td>van der Waals</td>
<td>sodium dodecyl sulfate (SDS), cetyltrimethylammonium bromide (CTAB)</td>
<td>2H-MoS$_2$</td>
<td>sonication</td>
<td>aqueous</td>
<td>stabilization in LPE</td>
</tr>
<tr>
<td>105</td>
<td>van der Waals</td>
<td>sodium cholate (SC)</td>
<td>2H-MoS$_2$</td>
<td>shear exfoliation</td>
<td>aqueous</td>
<td>stabilization in LPE</td>
</tr>
<tr>
<td>327</td>
<td>van der Waals</td>
<td>sodium deoxycholate (SDC)</td>
<td>2H-MoS$_2$</td>
<td>sonication</td>
<td>aqueous</td>
<td>stabilization in LPE, mixing with PVA for composite fabrication</td>
</tr>
<tr>
<td>328</td>
<td>van der Waals</td>
<td>sodium cholate (SC)</td>
<td>2H-WS$_2$</td>
<td>sonication</td>
<td>aqueous</td>
<td>stabilization in LPE for size selection</td>
</tr>
<tr>
<td>329</td>
<td>van der Waals</td>
<td>sodium cholate (SC)</td>
<td>2H-MoS$_2$, 2H-WS$_2$</td>
<td>dry ball milling</td>
<td>aqueous</td>
<td>stabilization</td>
</tr>
<tr>
<td>330</td>
<td>van der Waals</td>
<td>2,3,6,7,10,11-hexahydroxytriphenylene and derivatives</td>
<td>2H-MoS$_2$</td>
<td>sonication and dry ball milling</td>
<td>various</td>
<td>stabilization in LPE</td>
</tr>
<tr>
<td>Page</td>
<td>Author</td>
<td>Material</td>
<td>Treatment</td>
<td>Environment</td>
<td>Remarks</td>
<td></td>
</tr>
<tr>
<td>------</td>
<td>--------</td>
<td>----------</td>
<td>-----------</td>
<td>-------------</td>
<td>---------</td>
<td></td>
</tr>
<tr>
<td>331</td>
<td>van der Waals</td>
<td>sodium cholate (SC)</td>
<td>MoTe$_2$, WTe$_2$</td>
<td>sonication</td>
<td>aqueous</td>
<td>stabilization in LPE, mixing with PVA for composite fabrication</td>
</tr>
</tbody>
</table>

**Polymers or biopolymers**

polyoxyethylene sorbitan monooleate (Tween 80),
polyoxyethylene sorbitan trioleate (Tween 85),
polyvinylpyrrolidone (PVP),
polyoxyethylene dodecyl ether (Brij 30),
polyoxyethylene octadecyl ether (Brij 700),
polyoxyethylene octyl phenyl ether (Triton X-100),
gum arabic, Pluronic P-123,
n-Dodecyl β-D-maltoside (DBDM)
polybutadiene (PBD),
poly(styrene-co-butadiene) (PBS),
polystyrene (PS),
poly(vinyl chloride) (PVC),
poly(vinyl acetate) (PVAc),
polycarbonate (PC),
poly(methyl methacrylate) (PMMA),
poly(vinylidene chloride) (PVDC),
cellulose acetate (CA).

<p>| 332  | van der Waals | 2H-MoS$_2$, 2H-WS$_2$ | sonication | aqueous | stabilization in LPE |
| 333  | van der Waals | 2H-MoS$_2$, 2H-WS$_2$ | sonication | aqueous | stabilization in LPE |
| 334  | van der Waals | 2H-MoS$_2$, 2H-WS$_2$ | sonication | tetrahydrofuran | stabilization in LPE |
| 335  | van der Waals | 2H-MoS$_2$, 2H-WS$_2$ | sonication | aqueous | stabilization in LPE, photocatalysis |
| 336  | van der Waals | 2H-MoS$_2$, 2H-WS$_2$ | sonication | aqueous | stabilization in LPE, electrostatic layer by layer assembly |
| 337  | van der Waals | 2H-MoS$_2$, 2H-WS$_2$ | sonication | aqueous | thickness sorting in density gradient after LPE |
| 338  | van der Waals | 2H-MoS$_2$, 2H-WS$_2$ | sonication | aqueous | stabilization in LPE, cell labelling |
| 339  | van der Waals | 2H-MoS$_2$, 2H-WS$_2$ | sonication | aqueous | stabilization in LPE, chitosan composites |
| 340  | van der Waals | 2H-MoS$_2$, 2H-WS$_2$ | sonication | aqueous | Stabilization in LPE, farbication of H$_2$O$_2$ sensor |</p>
<table>
<thead>
<tr>
<th>Page</th>
<th>van der Waals</th>
<th>Component</th>
<th>Method</th>
<th>Stabilization/Property</th>
</tr>
</thead>
<tbody>
<tr>
<td>350</td>
<td>van der Waals</td>
<td>chitosan</td>
<td>2H-MoS₂ sonication after oleum pre-treatment aqueous</td>
<td>stabilization, chemotherapeutic drug nanocarrier</td>
</tr>
<tr>
<td>351</td>
<td>van der Waals</td>
<td>bovine serum albumin, then methylene blue</td>
<td>Acid-exfoliated WS₂ H₂SO₄ intercalation aqueous</td>
<td>stabilization, photosensitization</td>
</tr>
<tr>
<td>338</td>
<td>van der Waals</td>
<td>polyvinylpyrrolidone (PVP)</td>
<td>2H-MoS₂ sonication various</td>
<td>stabilization in LPE, film formation</td>
</tr>
<tr>
<td>339</td>
<td>van der Waals</td>
<td>Pluronic P123</td>
<td>2H-MoS₂ sonication aqueous</td>
<td>stabilization in LPE, anchor for AuNPs to enhance photocurrent</td>
</tr>
<tr>
<td>340</td>
<td>van der Waals</td>
<td>poly(ureamethylvinyl)silazane</td>
<td>Acid exfoliated MoS₂ chlorosulfonic acid exfoliation aqueous</td>
<td>formation of amorphous SiCN ceramic for Li ion batteries</td>
</tr>
<tr>
<td>401</td>
<td>van der Waals</td>
<td>polydopamine</td>
<td>1T-MoS₂ CE n-BuLi aqueous</td>
<td>stabilization after chemical exfoliation, nanoparticle decoration</td>
</tr>
<tr>
<td>352</td>
<td>van der Waals</td>
<td>bovine serum albumin</td>
<td>2H-MoS₂ sonication aqueous</td>
<td>stabilization in LPE, biocompatible nanosheets</td>
</tr>
<tr>
<td>353</td>
<td>van der Waals</td>
<td>DNA oligonucleotides</td>
<td>1T-MoS₂ CE n-BuLi aqueous</td>
<td>surface functionalization for a prostate specific antigen sensor</td>
</tr>
<tr>
<td>354</td>
<td>van der Waals</td>
<td>DNA oligonucleotides</td>
<td>2H-MoS₂ sonication (initially in SC) aqueous</td>
<td>stabilization at high ionic strength</td>
</tr>
<tr>
<td>355</td>
<td>van der Waals</td>
<td>nanofibrillated cellulose</td>
<td>2H-MoS₂ sonication aqueous</td>
<td>stabilization in LPE, composite formation</td>
</tr>
<tr>
<td>356</td>
<td>van der Waals</td>
<td>alkali lignin</td>
<td>2H-MoS₂, 2H-WS₂ sonication aqueous</td>
<td>stabilization in LPE</td>
</tr>
<tr>
<td>357</td>
<td>van der Waals</td>
<td>guar gum, xanthan gum, tannic acid</td>
<td>2H-MoS₂ sonication aqueous</td>
<td>stabilization in LPE, composite formation (epoxy resin) in tetrahydrofuran</td>
</tr>
<tr>
<td>358</td>
<td>van der Waals</td>
<td>chitosan</td>
<td>2H-MoS₂ sonication aqueous, then tetrahydrofuran</td>
<td>biocompatible nanosheets in water</td>
</tr>
<tr>
<td>359</td>
<td>van der Waals</td>
<td>chitosan</td>
<td>2H-MoS₂ ionic liquid (IL) assisted grinding IL, then aqueous</td>
<td>stabilization in LPE, biocompatible dispersions</td>
</tr>
<tr>
<td>341</td>
<td>van der Waals</td>
<td>19 different poloxamers (i.e., Pluronics and Tetronics)</td>
<td>2H-MoS₂ sonication aqueous</td>
<td>stabilization in LPE, composite fabrication</td>
</tr>
<tr>
<td>343</td>
<td>van der Waals</td>
<td>polyvinylalcohol (PVA)</td>
<td>2H-WS₂ sonication aqueous</td>
<td>stabilization in LPE, isolation of nanodots for HER</td>
</tr>
<tr>
<td>344</td>
<td>van der Waals</td>
<td>Pluronic F108</td>
<td>2H-WS₂ sonication aqueous</td>
<td>stabilization in LPE, composite fabrication</td>
</tr>
<tr>
<td>342</td>
<td>van der Waals</td>
<td>tetraphiafulvalene (TTF)-substituted polymers</td>
<td>1T-MoS₂ CE n-BuLi redispersion in tetrahydrofuran</td>
<td>stabilization after chemical exfoliation, chemical doping</td>
</tr>
<tr>
<td>Page</td>
<td>Author</td>
<td>Material Description</td>
<td>2D Material</td>
<td>Preparation Method</td>
</tr>
<tr>
<td>------</td>
<td>--------</td>
<td>----------------------</td>
<td>-------------</td>
<td>-------------------</td>
</tr>
<tr>
<td>360</td>
<td>van der Waals</td>
<td>DNA oligonucleotides</td>
<td>2H-WS$_2$, 2H-WSe$_2$</td>
<td>sonication</td>
</tr>
<tr>
<td>412</td>
<td>van der Waals</td>
<td>bovine serum albumin, then resveratrol</td>
<td>2H-MoS$_2$</td>
<td>sonication</td>
</tr>
<tr>
<td>361</td>
<td>van der Waals</td>
<td>cross-beta-amyloid (protein nanotubes)</td>
<td>2H-MoS$_2$</td>
<td>sonication</td>
</tr>
</tbody>
</table>
Table 3. Functionalization of solution-processed TMD nanosheets via coordination chemistry on defects (dative bonds of nucleophiles) and on basal plane (Lewis acid-base chemistry).

<table>
<thead>
<tr>
<th>Ref.</th>
<th>Suggested binding</th>
<th>Functional group</th>
<th>2D material</th>
<th>Exfoliation Method</th>
<th>Medium</th>
<th>Reason for functionalization</th>
</tr>
</thead>
<tbody>
<tr>
<td>259</td>
<td>thiol coordination to S vacancies</td>
<td>thiol-terminated polyethylene glycol with various headgroups</td>
<td>1T-MoS₂</td>
<td>CE n-BuLi</td>
<td>aqueous</td>
<td>proof of concept</td>
</tr>
<tr>
<td>379</td>
<td>thiol coordination to S vacancies + van der Waals</td>
<td>thioglycolic acid</td>
<td>2H-MoS₂</td>
<td>sonication</td>
<td>aqueous</td>
<td>stabilization in LPE</td>
</tr>
<tr>
<td>389</td>
<td>dithiolane coordination to S vacancies</td>
<td>lipoic acid conjugated polyethylene glycol</td>
<td>1T-WS₂, 1T-MoS₂</td>
<td>CE n-BuLi</td>
<td>aqueous</td>
<td>biocompatible nanosheets as theranostic agent or in drug delivery</td>
</tr>
<tr>
<td>380</td>
<td>thiol coordination to S vacancies</td>
<td>dithioglycol</td>
<td>1T-MoS₂</td>
<td>CE n-BuLi (hydrothermal)</td>
<td>tetrahydrofuran</td>
<td>nanocomposites with octa-vinyl polyhedral oligomeric silsesquioxanes (improved thermal, mechanical, flame-retardant properties)</td>
</tr>
<tr>
<td>381</td>
<td>thiol coordination to S vacancies</td>
<td>mercaptoundecanoic acid</td>
<td>2H-MoS₂</td>
<td>sonication (to introduce defects)</td>
<td>ethanol/H₂O</td>
<td>sensor for volatile organic compounds</td>
</tr>
<tr>
<td>382</td>
<td>thiol coordination to S vacancies</td>
<td>dodecanethiol</td>
<td>1T-MoS₂</td>
<td>CE n-BuLi</td>
<td>acetone</td>
<td>proof of concept: transfer to organic solvents</td>
</tr>
<tr>
<td>192</td>
<td>coordination of COOH to S vacancies (predominantly, at edges)</td>
<td>polyacrylic acid</td>
<td>2H-WS₂</td>
<td>sonication</td>
<td>aqueous</td>
<td>stabilization in LPE and fabrication of a biosensor with adsorbed ss-DNA</td>
</tr>
<tr>
<td>383</td>
<td>thiol coordination to S vacancies</td>
<td>mercaptopropionic acid, 1-Thioglycerol, L-Cysteine</td>
<td>1T-MoS₂</td>
<td>CE n-BuLi (hydrothermal)</td>
<td>aqueous</td>
<td>proof of concept; further derivatization by in situ reduction of metal ions, esterification, polymerizations</td>
</tr>
<tr>
<td>384</td>
<td>thiol coordination to S vacancies</td>
<td>meso-2,3-dimercaptosuccinic acid-modified iron oxide nanoparticles, then lipoic acid terminated polyethylene glycol and amine-terminated branched PEG</td>
<td>1T-MoS₂</td>
<td>CE n-BuLi</td>
<td>aqueous</td>
<td>TMD-based nanoplatform for multimodal imaging-guided photothermal therapy of cancer</td>
</tr>
<tr>
<td>112</td>
<td>thiol coordination to S vacancies</td>
<td>p-mercaptophenol, thiophenol, l-propanethiol, l-nonanethiol, and l-dodecanethiol</td>
<td>2H-MoS₂</td>
<td>two solvent grinding assisted sonication</td>
<td>ethanol</td>
<td>proof of concept (comparison of various thiols)</td>
</tr>
</tbody>
</table>
no thiol coordination, but physisorbed dimer

physisorbed cystine produced from cysteine

2H-MoS$_2$

sonication

isopropanol

proof of concept

S vacancies mainly at edges

lipolic acid

2H-MoS$_2$

sonication

aqueous

proof of concept

thiol coordination to S vacancies

thiol-terminated tetra ethylene glycol with various head groups

1T-MoS$_2$

CE $n$-BuLi

aqueous

2D material antibiotic

thiol coordination to S vacancies

thioglycolic acid

1T-MoS$_2$

CE $n$-BuLi (hydrothermal)

H$_2$O, H$_2$O/tetrahydrofuran for composite

polymer composite (chitosan, improved mechanical and thermal properties)

thiol coordination to S vacancies

N,N$'$-bis(p-thiophenylamido) diethylenetriamine-N,N$'$,N$''$-triacetic and complexation with Eu$^{3+}$ and Gd$^{3+}$

2H-MoS$_2$

sonication

isopropanol

proof of concept, introduction of magnetic and tailored light emission

thiol coordination to S/Se vacancies

thiobarbituric acid

1T-MoS$_2$, 1T-WS$_2$, 1T-MoSe$_2$, 1T-WSe$_2$

CE $n$-BuLi

aqueous

proof of concept, preservation of metallic 1T phase

sulfur addition at molybdenum edges

1,2-dithiolane derivatives bearing ethylene glycol alkyl chain terminated to a butoxycarbonyl (BOC)-protected amine or a pyrene

2H-MoS$_2$

acid-assisted liquid exfoliation (sonication)

chlorosulfonic acid, then dimethylformamide

proof of concept, fabrication of donor-acceptor hybrids

---

**Coordination chemistry on basal plane (Lewis acid-base chemistry)**

Metal (Cu$^{2+}$) ion coordination

cross-linking at edge sites *via* polymer

2H-MoS$_2$

sonication

dimethylformamide

mechanical robustness, polymer composite, reduced graphene oxide (rGO) composite as electrode in Li ion batteries

Metal ion (Cu$^{2+}$, Ni$^{2+}$, Zn$^{2+}$) coordination

acetates (*via* metal cations)

2H-MoS$_2$

sonication

isopropanol

proof of concept
Table 4. Reductive covalent basal plane functionalization of solution-processed TMDs with electrophiles. Notes: (*) Different intercalation conditions.

<table>
<thead>
<tr>
<th>Ref.</th>
<th>Reagent</th>
<th>Functional group</th>
<th>2D-material</th>
<th>Exfoliation Method</th>
<th>Medium</th>
<th>Reason for functionalization</th>
</tr>
</thead>
<tbody>
<tr>
<td>80</td>
<td>via alkyl halides, aryl diazonium salts</td>
<td>alkyl, 4-methoxybenzene</td>
<td>1T-MoS(_2), 1T-WS(_2), 1T-MoSe(_2)</td>
<td>CE n-BuLi</td>
<td>aqueous</td>
<td>proof of concept</td>
</tr>
<tr>
<td>260</td>
<td>via aryldiazonium salts</td>
<td>4-methoxybenzene</td>
<td>1T/2H-MoS(_2)</td>
<td>CE n-BuLi (*</td>
<td>aqueous</td>
<td>proof of concept</td>
</tr>
<tr>
<td>196</td>
<td>via 4-carboxy-benzenediazonium salt</td>
<td>4-carboxybenzene</td>
<td>1T-MoS(_2)</td>
<td>CE n-BuLi</td>
<td>dimethylformamide (DMF)</td>
<td>reference system to edge functionalized 2H-MoS(_2) in thin film transistor</td>
</tr>
<tr>
<td>78</td>
<td>via organohalides</td>
<td>benzene, 4-methoxybenzene, 4-nitrobenzene, porphyrin, pyrene derivatives</td>
<td>1T-MoS(_2), 1T-MoSe(_2), 2H-MoS(_2) and 2H MoSe(_2) (with Pd(_0) catalyst)</td>
<td>CE n-BuLi, sonication</td>
<td>H(_2)O/DMF (1T), DMF (2H)</td>
<td>proof of concept</td>
</tr>
<tr>
<td>373</td>
<td>via 4-Cyanobenzyl diazonium salt</td>
<td>4-cyanobenzol and coordination to cobaloxime</td>
<td>1T-MoS(_2)</td>
<td>CE n-BuLi</td>
<td>aqueous</td>
<td>improved HER electrocatalyst</td>
</tr>
<tr>
<td>374</td>
<td>via 5-Bromomethyl-2,2'-bipyridine</td>
<td>methyl-2,2'-bipyridine and coordination to RuI(bpy)2Cl(_2)</td>
<td>1T-MoS(_2)</td>
<td>CE n-BuLi</td>
<td>H(_2)O/ethanol</td>
<td>improved HER electrocatalyst</td>
</tr>
</tbody>
</table>
Table 5. Decoration of solution-processed TMDs with noble metal nanoparticles.

<table>
<thead>
<tr>
<th>Ref.</th>
<th>Method/suggested binding</th>
<th>Nanoparticle and 2D material</th>
<th>Exfoliation Method</th>
<th>Precursor Salt</th>
<th>Reducing Agent</th>
<th>Reason for functionalization</th>
</tr>
</thead>
<tbody>
<tr>
<td>394</td>
<td>epitaxial growth on basal plane</td>
<td>Pd, Pt, Au on MoS₂</td>
<td>electrochemical Li intercalation</td>
<td>K₂PdCl₄, K₂PtCl₄, HAuCl₄</td>
<td>Pd: CTAB/ascorbic acid; Pt: trisodium citrate; Au: Trisodium citrate</td>
<td>proof of concept, hybrids for electrocatalysis</td>
</tr>
<tr>
<td>395</td>
<td>spontaneous formation at defect sites and edges (physisorption)</td>
<td>Au on 1T-MoS₂, 1T-WS₂</td>
<td>CE n-BuLi</td>
<td>HAuCl₄</td>
<td>none</td>
<td>proof of concept, hybrids for electrocatalysis</td>
</tr>
<tr>
<td>409</td>
<td>metal nuclei seeding on defect sites (basal plane)</td>
<td>Au, Ag on 2H-MoS₂</td>
<td>sonication in NMP</td>
<td>HAuCl₄, AgNO₃</td>
<td>hydroxyl amine, microwave</td>
<td>proof of concept, improve transport behavior</td>
</tr>
<tr>
<td>396</td>
<td>self-assembly on basal plane</td>
<td>Au on 2H-MoS₂</td>
<td>L-cysteine assisted exfoliation</td>
<td>HAuCl₄</td>
<td>NaBH₄</td>
<td>fabrication of an aptasensor via layer by layer deposition</td>
</tr>
<tr>
<td>397</td>
<td>self-assembly on basal plane</td>
<td>Ag on 2H-MoS₂</td>
<td>sonication in NMP (+ chitosan stabilizer)</td>
<td>AgNO₃</td>
<td>ascorbic acid</td>
<td>electrocatalysis (tyrosin oxidation)</td>
</tr>
<tr>
<td>398</td>
<td>epitaxial growth on basal plane</td>
<td>Au on MoS₂</td>
<td>electrochemical Li intercalation</td>
<td>HAuCl₄</td>
<td>ascorbic acid</td>
<td>Au NP plasmon enhanced photocatalytic water-splitting</td>
</tr>
<tr>
<td>399</td>
<td>self-assembly on basal plane (physisorption)</td>
<td>Au, Ag, Pt, Pd on 1T-MoS₂</td>
<td>CE n-BuLi (+carboxymethyl cellulose stabilizer)</td>
<td>HAuCl₄, AgNO₃, H₂PtCl₆, PdCl₂</td>
<td>microwave</td>
<td>proof of concept, Pd-MoS₂ for electrocatalysis (methanol oxidation)</td>
</tr>
<tr>
<td>383</td>
<td>growth on COOH on basal plane functionalized MoS₂</td>
<td>Ag on functionalized MoS₂</td>
<td>thiol coordination after CE</td>
<td>AgNO₃</td>
<td>NaBH₄</td>
<td>proof of concept</td>
</tr>
<tr>
<td>400</td>
<td>growth on COOH on basal plane functionalized MoS₂</td>
<td>Pt, Au, FeO₄, CdS₂, PbS on functionalized MoS₂</td>
<td>thiol coordination after CE</td>
<td>K₂PtCl₆, HClAu₄, FeCl₃, CdCl₂, Pb(CH₃COO)₂</td>
<td>Pt, Au: NaBH₄; FeO₄: NaOH; CdS₂ and PbS: Na₂S</td>
<td>proof of concept, production of ternary systems for photocatalysis (reduction of 4-nitrophenol)</td>
</tr>
<tr>
<td>339</td>
<td>growth on MoS₂ edges and basal plane</td>
<td>Au on 2H-MoS₂</td>
<td>sonication in aqueous Pluronic P123</td>
<td>HAuCl₄</td>
<td>none</td>
<td>cathode buffer layers in organic photovoltaic devices</td>
</tr>
<tr>
<td>401</td>
<td>growth on poly dopamine layer surrounding MoS₂</td>
<td>Pt, Au on 1T-MoS₂ with self-polymerised dopamine</td>
<td>CE, reaction with dopamine hydrochloride</td>
<td>H₂PtCl₆, HAuCl₄</td>
<td>none</td>
<td>proof of concept, photocatalysis</td>
</tr>
<tr>
<td>372</td>
<td>growth on COOH on basal plane functionalized MoS$_2$</td>
<td>Ag on functionalized 1T-MoS$_2$</td>
<td>CE and reductive functionalization</td>
<td>AgNO$_3$</td>
<td>NaBH$_4$</td>
<td>proof of concept</td>
</tr>
<tr>
<td>402</td>
<td>growth on PVP on basal plane of MoS$_2$ (physisorption)</td>
<td>Au, Au/Pt on 1T-MoS$_2$ with PVP coating</td>
<td>CE $n$-BuLi</td>
<td>HAuCl$_4$, then H$_2$PtCl$_6$</td>
<td>none for Au, then CTAB/acetic acid for Pt</td>
<td>electrocatalysis (oxidation of methanol)</td>
</tr>
<tr>
<td>410</td>
<td>spontaneous formation binding to defect sites and edges (physisorption)</td>
<td>Au on 1T-MoS$_2$</td>
<td>CE $n$-BuLi</td>
<td>HAuCl$_4$</td>
<td>none</td>
<td>further derivatization via thiol click chemistry</td>
</tr>
<tr>
<td>403</td>
<td>growth on PVP on basal plane and edge (physisorption)</td>
<td>Pd on 2H-WS$_2$</td>
<td>LPE in NMP, (+ PVP, ethylene glycol)</td>
<td>Pd(OAc)$_2$</td>
<td>ethylene glycol</td>
<td>photocatalysis (Suzuki reactions)</td>
</tr>
<tr>
<td>404</td>
<td>chemisorption through reaction with thiol edge sites (and basal plane defects to minor extent)</td>
<td>Au on 2H-WS$_2$</td>
<td>LPE in aqueous SC</td>
<td>HAuCl$_4$</td>
<td>none</td>
<td>proof of concept (different mechanism resulting in chemisorption), monolayer enrichment, electrocatalytic hydrogen evolution</td>
</tr>
</tbody>
</table>
Table 6. Additional methods for the functionalization of solution-processed TMD nanosheets.

<table>
<thead>
<tr>
<th>Ref.</th>
<th>Type of reaction</th>
<th>Functional group</th>
<th>Layered material</th>
<th>Exfoliation Method</th>
<th>Medium</th>
<th>Reason for functionalization</th>
</tr>
</thead>
<tbody>
<tr>
<td>413</td>
<td>oxidation</td>
<td>oxides and chlorosulfonic acid</td>
<td>2H-WS₂</td>
<td>acid intercalation and oxidation</td>
<td>chlorosulfonic acid, then water</td>
<td>proof of concept, electrode in Li ion battery</td>
</tr>
<tr>
<td>193</td>
<td>coordination to negatively charged S-edge</td>
<td>thionine</td>
<td>2H-MoS₂</td>
<td>ionic liquid assisted sonication</td>
<td>ionic liquid (IL), then DMF</td>
<td>fabrication of a double-stranded DNA electrochemical biosensor</td>
</tr>
<tr>
<td>391</td>
<td>binding of edge S to polybutadiene</td>
<td>polybutadiene</td>
<td>2H-MoS₂</td>
<td>sonication</td>
<td>N-methyl-2-pyrrolidone</td>
<td>proof of concept, polymer composite</td>
</tr>
<tr>
<td>196</td>
<td>reaction of 4-carboxybenzenediazonium salt with S-rich edges in the presence of amine</td>
<td>4-carboxybenzene</td>
<td>2H-MoS₂</td>
<td>“solvation” in dimethylformamide (DMF)</td>
<td>DMF</td>
<td>cross-linking of edges of functionalized 2H-MoS₂ via hydrogen bonding in thin film transistor</td>
</tr>
</tbody>
</table>
6. Recent progress in the chemistry of TMDs “beyond MoWSeS”

Besides MoWSeS materials, other TMDs (group-6 tellurides, groups 4, 5, 7 and 10) possessing diverse chemical and physical properties are attracting nowadays a great deal of attention. In general, the electronic structures of TMDs are strongly dependent on the d-electron number of the transition metal. TMDs with many (group 7, 10) or few (group 4) d-electrons are prone to form $d^3sp^3$ hybridization, which results in the 1T-phase (or distorted 1T') structure. In terms of electronic transport, they mostly exhibit semiconducting properties. In contrast, TMDs of the group 5 and 6 are prone to form $d^4sp$ hybridization with 1H structure and behave as narrow-band metals or semimetals with superconducting properties. By taking advantage of chemical functionalization strategies, diverse and novel properties of TMDs may emerge and be used for device applications.

The interaction between ferromagnetism (FM) and superconductivity (SC) is a cutting-edge research topic. It is well known that FM can destroy singlet correlations responsible for SC, and therefore it is quite rare to find materials that simultaneously exhibit both properties. Recently, the coexistence of FM and SC was observed in chemically-exfoliated 2H-NbSe$_2$ (group 5) nanosheets upon chemical treatment with hydrazine molecules. Pristine NbSe$_2$ is a superconducting yet non-magnetic material since the magnetic moment of Nb$^{4+}$ ($4d^1$ configuration) is quenched due to the Nb-Se hybridization. Zhu et al. found that the adsorption of reducing hydrazine molecules on the surface of NbSe$_2$ (Fig. 18a) induces a structural distortion, i.e. elongated Nb-Se bonds and weaker Nb-Se interactions. Such a distortion leads to the emergence of a net magnetic moment with ordered spin behaviour resulting in ferromagnetic properties. Fig. 18b displays the magnetic hysteresis loop at 30 K, which provides evidence for the existence of FM in NbSe$_2$. Moreover, the abrupt drop in electrical resistivity $R$ occurring at temperature $T \leq 6$ K (see Fig. 18c) confirms that the hydrazine treatment does not suppress the SC properties. Hence, the adsorption of hydrazine
molecules is an effective method to modulate the electrical — see also discussion in Section 2.1 — and magnetic properties of TMDs via chemical approaches.

Monolayer MoTe$_2$ (group 6) has emerged as a promising phase-change material due to the small energy difference ($\sim$31 meV)$^{417}$ between the semiconducting 1H and metallic 1T' polytypes,$^{146,147}$ which makes it possible to trigger phase transitions via electrostatic doping.$^{147}$ Theoretical calculations by Zhou et al.$^{417}$ predict that molecules (e.g. H$_2$, H$_2$O, NH$_3$, CO and N$_2$) and atoms (e.g. Li, Na, K, O and Cl) adsorbed on the surface of the 2D sheet can stabilize the 1H and 1T' phase, respectively. In this framework, new experimental studies are foreseen to explore the use of molecular approaches — for instance based on the “decoration” of the top and bottom surface (see Section 2.2) — to control the phase state and therefore also the electrical properties of ultrathin MoTe$_2$.

Group-10 TMDs are gathering attention due to their thickness-dependent bandgap and high charge-carrier mobility.$^{144,414}$ For instance, bulk PdSe$_2$ and PtSe$_2$ are semimetals whereas thin sheets of these materials (thickness $\leq$ 10 nm) display small semiconducting bandgaps.$^{144,411}$ FETs based on $\sim$9 nm thick sheets of PdSe$_2$ (group-10) show ambipolar transport characteristics with electron/hole field-effect mobility ($\mu_{FE}$) up to $\sim$54/14 cm$^2$V$^{-1}$s$^{-1}$ and $I_{on}/I_{off}$ ratio of $\sim$100.$^{113}$ After a thermal annealing step under vacuum, which is commonly performed to remove environmental adsorbates (i.e. H$_2$O and O$_2$), the devices show unipolar $n$-type transport with $\mu_{FE}$ $\approx$ 216 cm$^2$V$^{-1}$s$^{-1}$ and $I_{on}/I_{off}$ $\approx$ 10$^3$ (Fig. 18d). However, ambipolar as well as unipolar $p$-type transport has also been achieved via physisorption of acceptor molecules, namely F$_4$-TCNQ (see Section 2.1). Electrical transport measurements in Fig. 18e demonstrate that the charge-carrier density in F$_4$-TCNQ-treated PdSe$_2$ FETs can be effectively modulated by controlling the amount of physisorbed molecules. By increasing the number of molecular dopants, the authors succeeded in achieving a unipolar $p$-type transport (red curve in Fig. 18e). Overall, they showed that the combination of thermal annealing and molecular
Physisorption doping is a promising route to control the charge-carrier polarity in narrow-bandgap semiconductors towards complementary logic devices and circuits.

Wan et al.\textsuperscript{418} prepared and characterized a promising \textit{n}-type flexible thermoelectric material based on hybrid superlattices of semiconducting 1T-TiS\textsubscript{2} (group 4) and organic cations. TiS\textsubscript{2} single crystals were electrochemically intercalated with hexylammonium (HA) ions dissolved in dimethyl sulfoxide (DMSO). After solvent exchange from DMSO to water the resulting compound — \textit{i.e.} TiS\textsubscript{2}[(HA)\textsubscript{0.08}(H\textsubscript{2}O)\textsubscript{0.22}(DMSO)\textsubscript{0.03}] — showed a remarkably low in-plane thermal conductivity (~0.12 Wm\textsuperscript{-1}K\textsuperscript{-1}), significantly lower than that of pristine TiS\textsubscript{2} crystals (4.2 Wm\textsuperscript{-1}K\textsuperscript{-1}) where the layers interact \textit{via} weak van der Waals forces. On the other hand, negatively-charged TiS\textsubscript{2} layers and organic cations in the hybrid system are coupled \textit{via} strong electrostatic interactions,\textsuperscript{418} which degrade the in-plane thermal conductivity due to phonon scattering. The combination of high electrical conductivity — typical of TiS\textsubscript{2} — with the low thermal conductivity of the intercalated compound, allowed achieving a figure of merit $ZT$ as high as ~0.28 ($T \approx 373$ K), which is close to that of the most promising \textit{p}-type organic thermoelectric materials, \textit{i.e.} poly(3,4-ethylenedioxythiophene) polystyrene sulfonate (PEDOT:PSS).

Finally, ultrathin ReSe\textsubscript{2} (group 7) is an appealing material for optoelectronic applications due to its wide photoresponse range. The performance of photodetectors based on ReSe\textsubscript{2} nanosheets has been significantly improved by \textit{n}-type doping \textit{via} physisorption of triphenylphosphine (PPh\textsubscript{3}) molecules.\textsuperscript{101} In comparison to their untreated counterparts, PPh\textsubscript{3}-treated ReSe\textsubscript{2} FETs were found to display lower contact resistance, higher charge-carrier mobility, as well as enhanced photocurrent — by approximately a factor of 4 — under monochromatic light irradiation ($\lambda \approx 520$ nm).

By taking advantage of the exotic properties of TMDs beyond group 6 and of their tunability \textit{via} molecular chemistry methods, advanced optoelectronic, magnetic, as well as
thermoelectric materials can be developed, paving the way towards novel applications based on molecule-TMD hybrids.

7. Conclusions and outlook

The large variety of materials/properties available in the TMD family combined with the virtually-infinite number of functional molecular systems available through chemical synthesis provide countless opportunities to engineer hybrid organic/inorganic nanomaterials with on-demand characteristics for device applications. In such hybrids, new functionalities can be introduced in a chemically controlled manner by tailoring the interactions between molecules ultrathin crystalline materials, thereby opening further possibilities for developing multifunctional/multiresponsive materials and devices. Hereafter, we will discuss these newly emerging research fronts, as well as the prospects and the challenges towards next-generation technologies based on molecule-TMD hybrid materials.

Hybrid van der Waals heterostructures. The molecular chemistry approaches to TMDs present several analogies to the quest for materials by design carried out by superimposing different inorganic 2D materials in the so-called van der Waals heterostructures (Fig. 19a). Molecules can be incorporated into these layered structures to generate novel hybrid materials in which unique molecular capabilities are combined with the ultra-high electrical performances of TMDs and other 2D materials. Towards this goal, molecular science offers a variety of opportunities which have not yet been fully exploited.

So far, relatively few studies exploit the possibility to generate highly predictable self-assembled molecular monolayers on the surface of TMDs and impart them on-demand functions. Indeed, the molecular arrangement on TMD surfaces is determined by supramolecular interactions which can be predicted and controlled by molecular design. Mastering molecular self-assembly offers the possibility to incorporate specific functional
groups (such as dopants) at pre-determined spatial locations, paving the way to a direct correlation between electrical effects measured at the device level and events taking place at the molecular scale. Moreover, such molecular chemistry approaches ensure an atomic precision that outperforms conventional lithographic techniques,\textsuperscript{423-425} and molecular monolayers self-align with respect to the crystalline direction of the underlying substrate giving rise to epitaxial growth.\textsuperscript{426, 427} On graphene, this approach was exploited to induce controllable periodic potentials\textsuperscript{93} and demonstrate tunable doping.\textsuperscript{428}

The same ultra-high control over the nanoscale molecular ordering can be achieved in the case of TMDs.\textsuperscript{81} Recently, Wang \textit{et al.}\textsuperscript{252} demonstrated that oleamide generates analogous crystalline structures on the surface of different 2D materials, including several TMDs - MoS\textsubscript{2}, MoSe\textsubscript{2}, MoTe\textsubscript{2}, WSe\textsubscript{2} (Fig. 19 b-d). Within the SAMs, oleamide molecules lie flat on the substrate surface, and intermolecular hydrogen bonds drive the formation of parallel rows, which are aligned to the crystallographic orientation of the 2D materials (Fig.16e). In this regard, the growth is epitaxial and atomically precise, with single crystalline molecular domains extending over regions above 0.5 \(\mu m\) \(\times\) 0.5 \(\mu m\) (Fig.16 b-d).\textsuperscript{252} Whether the structural 1D anisotropy of the assembly induces anisotropy in the electronic properties of the underlying TMD remains an open question, which can only be answered by an investigation of electrical transport and optical characteristics of regions covered by a single crystalline molecular domain. In turn, this goal poses the challenge of maximizing the size of molecular crystalline domains, and of fabricating nanoscale device which preserve the molecular monolayers. Finally, we highlight that molecular decoration affects not only the optoelectronic, but also the magnetic properties of TMDs,\textsuperscript{114, 429} opening interesting avenues for spintronics based on TMD/molecules heterostructures. In perspective, the ability to generate heterostructures with engineered properties can be exploited to build up a library of novel hybrid materials with on-demand properties.
**Multifunctional materials and devices.** Combining molecular systems with ultrathin TMDs allows not only to control the charge-carrier doping of 2D semiconductors but also to modulate their optical, thermal and sensing properties in hybrid systems. Such an approach makes it also possible to impart a multifunctional/multiresponsive nature to 2D TMDs that can be conveniently exploited for developing multifunctional (opto)electronic devices, which can be controlled with multiple independent stimuli. For instance, by making use of the different molecular chemistry methods discussed in this review, 2D sheets of TMDs could be functionalized with molecules carrying photochromic, magneto-responsive and electrochemically-switchable moieties. External stimuli, such as heat, light, magnetic fields and electrochemical signals, can then be used to trigger changes in the structures/properties of the molecules interfacing the ultrathin sheets. Thanks to their ultimately-large surface to volume ratio, ultrathin TMDs are expected to respond to such changes with variations in their electrical, optical and magnetic characteristics. One interesting example has been recently provided by Datta et al.,\textsuperscript{429} who developed FETs based on monolayer MoS\textsubscript{2} sheets “decorated” on the top surface with magnetic molecules, such as quinoidal dithienyl perylenequinodimethane (QDTP). The latter undergo a spin transition from a singlet to a triplet state with increasing temperature above \( \sim 370 \) K. This spin-state switch could be electrically transduced by the MoS\textsubscript{2} sheet, which displayed an increase in the free electron density \((n\text{doping})\) and a strong enhancement in magnetoconductance \((\sim 100\%)\) above the magnetic transition temperature. This work demonstrated that the electrical/magnetic properties of monolayer MoS\textsubscript{2} could be dynamically modified through the interaction with switchable molecular systems. In the next years, further research is envisioned towards multifunctional/multiresponsive materials and devices based on combinations of ultrathin TMDs and molecular switches.
Next challenges. In order to take full advantage of TMD-molecule hybrids in technological applications, various challenges have to be addressed. Besides the aforementioned requirement to control/enlarge the size of physisorbed molecular crystal domains, an important task towards hybrid TMD-molecule (opto)electronics consists in developing suitable techniques (e.g. encapsulation) to prevent desorption or decomposition of molecules during device operation. It is also of paramount importance to achieve a systematic control over the degree of functionalization in both solution-processed and substrate-supported 2D sheets. The latter should be carefully quantified through multiple experimental techniques and must be systematically controlled, especially in the case of optoelectronic devices and sensing technologies, where uniform and reproducible optical, electronic and sensing properties must be achieved across the entire active material’s surface. However, such requirement might not be so stringent for multifunctional foams and composites, or for biomedical applications, which could be the first areas where hybrid molecule-TMDs could find practical application, in order to address societal needs in energy generation and storage as well as water purification and highly selective gas and ion sensors. Towards the improvement of the quality of our lives, in the forthcoming years the development of structurally defined, novel hybrid materials based on TMDs and suitably designed molecules, shall open a new technological era relying on portable, flexible and foldable multiresponsive (opto)electronic devices for health and environmental monitoring. The full exploitation of the infinite options offered by molecular science in terms of structural and functional diversities shall soon yield to the emergence of new, disruptive and exotic technologies based on TMDs hybrids.

Conflict of interest

There are no conflicts to declare.
Acknowledgments

We acknowledge funding from the European Commission through the Graphene Flagship (GA-696656), the Marie-Curie IEF MULTI2DSWITCH (GA-700802) and the Marie Curie IEF SUPER2D (GA-748971), the M-ERA.NET project MODIGLIANI, the Agence Nationale de la Recherche through the LabEx projects CSC (ANR-10-LABX-0026 CSC) and Nanostructures in Interaction with their Environment (ANR-11-LABX-0058 NIE) within the Investissement d’Avenir program (ANR-10-120 IDEX-0002-02), and the International Center for Frontier Research in Chemistry (icFRC). C.B. acknowledges the German research foundation DFG under Emmy-Noether grant BA4856/2-1.
References

76. S. Presolski and M. Pumera, Mater. Today, 2016, 19, 140.
89. S. N. Zhang, C. J. Benjamin and Z. Chen, presented in part at the 75th Annual Device Research Conference, South Bend, IN, USA, June, 2017.


Figures

**Fig. 1** Schematic representation of the different molecular chemistry approaches that have been investigated in the last years for tailoring the properties of ultrathin TMDs.
**Fig. 2** Crystal structures and defects in monolayer TMDs. (a) Schematic illustration of the 1H (left) and 1T (right) polytypes, as seen along the $c$-axis (top) and $a$-axis (bottom) of the crystal. (b) Three-dimensional representation of the most common coordination geometries between M and X atoms. (c) Structure of single ($V_X$) and double ($V_{X2}$) chalcogen vacancies in 1H TMDs. (d) Atomic-resolution annular dark field (ADF) TEM images of single (left) and double (right) SVs present in monolayer MoS$_2$ sheets grown by CVD. (d) Adapted with permission from ref. 158. Copyright 2013 American Chemical Society.
Fig. 3 Comparison between the electrochemical redox potentials of various molecular dopants and the band edges of group-6 TMDs. Approximate reduction potentials (eV vs vacuum) were derived from values reported in literature, namely hydrazine (N$_2$H$_4$), benzyl viologen (BV), magnesium phtalocyanine (MgPc), nickle phtalocyanine (NiPc), nicotinamide adenine dinucleotide (NADH), tetracyanoquinodimethane (TCNQ), tetrafluoro-7,7,8,8-tetracyanoquinodimethane (F$_4$-TCNQ), tris(4-bromophenyl)-ammoniumyl hexachloroantimonate (Magic Blue). The CBM/VBM band edges (theoretical values) were taken from ref. 210.
Fig. 4 Modulation of PL and electrical transport via molecular physisorption. (a) Effect of \( p \)-dopant TCNQ and \( F_4 \)-TCNQ molecules, as well as (b) \( n \)-dopant NADH molecules on the PL spectra of monolayer (1L) MoS\(_2\) sheets prepared by micromechanical cleavage. (c) Fitting of the PL spectra of as-prepared and \( F_4 \)-TCNQ-doped 1L-MoS\(_2\). The A peaks were fitted with trion (X-) and neutral exciton (X) contributions. (d) Transfer curves of a 1L-WS\(_2\) FET for different concentrations of \( F_4 \)-TCNQ molecules. (a-c) Adapted with permission from ref. 209. Copyright 2013 American Chemical Society. (d) Adapted with permission from ref. 216. Copyright 2014 American Chemical Society.
Fig. 5 Influence of physisorbed molecules on the Raman spectra of TMDs. (a) Raman spectra of few-layer MoS$_2$ sheets before and after different treatment with (2-Fc-DMBI)$_2$. (b-d) $E_{2g}^1$ (squares) and $A_{1g}$ (circles) peak position shifts upon doping with (2-Fc-DMBI)$_2$, 2-Fc-DMBI-H and “Magic Blue”, respectively. (a-d) Adapted with permission from ref. 87. Copyright 2015 Wiley-VCH.
Fig. 6 Doping of TMDs by MPcs. (a) Schematic representation of a TMD sheet and a metallophthalocyanine molecule (MPc). (b, c) PL spectra of MoS$_2$, MoSe$_2$, and WSe$_2$ before and after physisorption of (b) NiPc and (c) MgPc. (a-d) Reprinted with permission from ref. 99. Copyright 2016 American Chemical Society.
Fig. 7 Effects of polymer substrates on TMDs. (a) Structure of the FET device used to investigate the effects of polymer films on the charge-transport properties of ultrathin TMDs. (b) Transfer characteristics of few-layers MoSe₂ FETs built on parylene and SiO₂ substrates. (c) PL spectra of monolayer MoS₂ sheets deposited on different substrates. (d) Gate-voltage dependence of the PL intensity of monolayer MoS₂ on Cytop and SiO₂. Inset: PL spectra of monolayer MoS₂ on Cytop at various gate voltages. (b) Adapted with permission from ref. 205. Copyright 2014 American Chemical Society. (c, d) Adapted with permission from ref. 206. Copyright 2016 Wiley-VCH.
Fig. 8 The effect of SAM-modified substrates on TMDs. (a) Highly ordered molecules within the SAM are chemisorbed on the substrate surface and interact through weak van der Waals forces with TMD sheets deposited onto them. The chemical structure of the three silane coupling agents used in ref. 84 is also shown. (b) Transfer characteristics of few-layers MoS$_2$ onto the different SAMs. (c) Cartoon of photoswitchable AZO-SAM on gold substrates interacting with MoS$_2$. (d) Modification of the MoS$_2$ PL intensity accompanying the AZO-SAM switch. (e) Light-induced modulation of the electrical current flowing vertically across the SAM (from gold to MoS$_2$). (b) Adapted with permission from ref. 84. Copyright 2013 American Chemical Society. (c, d) Reprinted with permission from ref. 222. Copyright 2014 American Institute of Physics. (e) Adapted with permission from ref. 247. Copyright 2015 Wiley-VCH.
**Fig. 9** Highly-ordered molecular layers on TMDs. (a) Schematic diagram of back-gated TMD transistors modified by ODTS or APTES treatments of the top surface. (b) Transfer characteristics of clean and ODTS-treated few-layer WSe$_2$ FETs built on SiO$_2$ substrates. (c) Threshold voltage shifts measured in few-layer TMD FETs treated with different molecules. Adapted with permission from ref. 39. Copyright 2015 Wiley-VCH.
Fig. 10 Enhancement of the TMD PL by acid treatments. (a) PL spectrum for as-exfoliated and TFSI-treated MoS$_2$ monolayers. Inset: normalized spectra. The chemical structure of TFSI is also shown. (b) PL intensity maps of the same MoS$_2$ monolayer before and after the TFSI treatment. (c) Quantum yield dependence on the pump power, extracted from calibrated photoluminescence measured at different incident power. (d-e) PL intensity maps of an individual CVD-grown MoSe$_2$ monolayer before and after the HBr treatment. (f) PL spectra of pristine and HBr-treated MoSe$_2$ flake. (a-c) Reprinted with permission from ref. 97. Copyright 2015 AAAS. (d-f) Reprinted with permission from ref. 100. Copyright 2016 American Chemical Society.
Fig. 11 Engineering chemically-active defects in ultrathin TMDs. (a-c) Aberration-corrected HR-TEM images demonstrating the generation of SVs via electron irradiation at 80 keV and the subsequent filling by impurity atoms. The red arrow in (a) indicates an initial SV that is filled by an impurity atom between (b) and (c), whereas the green arrow indicates a S atom that is ejected between (a) and (b) leaving a single vacancy. (d) Evolution of the stoichiometric ratio — as obtained from XPS measurements — of large-area CVD MoS$_2$ films exposed to an increasing dose of low-energy ($E \approx 500$ eV) argon ions. (e) Schematics of the ion-bombardment experiment performed on monolayer MoS$_2$ FETs. (f) Evolution of the transfer characteristics of the FET schematized in (e) with increasing density of SVs. (g) Experimental and theoretical evolution of the field-effect mobility $\mu_{FE}$ and $I_{on}/I_{off}$ ratio (inset) with SV density. (a-c) Reprinted with permission from ref. 68. Copyright 2012 American Physical Society. (d) Reproduced with permission from ref. 274. Copyright 2013 IOP Science. (e-g) Reproduced with permission from ref. 109. Copyright 2017 Wiley-VCH.
**Fig. 12** Repair/functionalization of chemically-active defects in MoS$_2$. (a, b) Schematic representation of the STM experiments on the adsorption (a) and dissociation (b) of thiol molecules on the surface of a bulk 2H-MoS$_2$ crystal. (c) Kinetics and transient states of the reaction between a single SV and MPS. (d, e) Effect of the MPS treatment on the transfer characteristics (d) and field-effect mobility (e) of monolayer MoS$_2$ FETs. Black: no treatment. Blue: top surface treatment. Red: bottom and top surface treatment. (f) Molecular dopants with thiol anchoring groups. The molecules have same spacer group (two carbon atoms) between the doping and anchoring units. (g) Transfer characteristics of untreated (black), FDT-treated (blue) and MEA-treated (red) few-layer MoS$_2$ FETs. (a, b) Adapted with permission from ref. 181. Copyright 2012 American Chemical Society. (c-e) Adapted with permission from ref. 182. Copyright 2014 Nature Publishing Group. (f, g) Adapted with permission from ref. 88. Copyright 2015 American Chemical Society
Fig. 13 Covalent functionalization of MoS$_2$ via phase engineering. (a) Schematics of the functionalization approach based on the reaction of 1T-MoS$_2$ nanosheets with organohalides. (b) Electrostatic force microscopy phase image of a CVD-grown MoS$_2$ sheet with locally patterned metallic and semiconducting regions. Scale bar: 1 µm. (c) High annular angle dark field scanning TEM images of functionalized monolayer MoS$_2$ sheets with octahedral coordination. Scale bar: 0.5 nm. (d) PL spectra of a CVD-grown MoS$_2$ sheet at different stages of the functionalization process: pristine (black), after exposure to $n$-butyllithium (blue) and after functionalization (red). (a, c, d) Adapted with permission from ref. 80. Copyright 2015 Nature Publishing Group. (b) Reproduced with permission from ref. 308. Copyright 2014 Nature Publishing Group.
**Fig. 14** Overview of functionalization strategies for TMDs in the liquid phase based on chemically exfoliated (CE-MX$_2$) and liquid phase exfoliated (LPE-MX$_2$) nanosheets. In addition to physisorption, different approaches for chemisorption exist. These can be classified as covalent (involving X-C bonds), coordinative (involving chalcogens as ligands) and defect functionalization. Defects such as chalcogen vacancies can also be used for coordination chemistry involving dative bonds with nucleophiles.
Fig. 15 Schematic of reaction pathways to achieve functionalization via chemisorption.

(a) Pathways building on chemical exfoliation via intercalation with n-butyllithium. This process yields negatively charged MX$_2$ nanosheets in the 1T/1T$'$ polytype which can be further derivatized via i) coordination of thiols to chalcogen vacancy sites (defect functionalization), ii) reductive covalent functionalization with electrophiles such as organohalides or diazonium salts, or iii) physisorption of metal nanoparticles.

(b) Pathways building on liquid phase exfoliation in appropriate solvents or aqueous surfactants. This strategy yields few-layered nanosheets of the semiconducting 2H-polytype. These can be functionalized by i) coordination of electron donors (dithiolanes or carboxylic acids) to sulfur deficient edges, ii) coordination to metal complexes using the chalcogen as ligand, or iii) nanoparticles covalently bound to nanosheet edges.
**Fig. 16** Covalent reductive and coordinative functionalization of MX$_2$ in liquids. (a, b) Reductive covalent functionalization according to ref. 80. (a) Sulfur XPS core level spectra showing evidence for an additional sulfur species due to the formation of a covalent S-C bond. (b) IR spectra 1T-MoWSe$_2$ reductively functionalized with iodomethane. From top to bottom: iodomethane (green), functionalized 1T-MoS$_2$ (red), 1T-WS$_2$ (blue) and 1T-MoSe$_2$ (orange). (c-e) Tuning of 2H/1T content in MoS$_2$ via intercalation conditions. (c, d) Mo core level spectra after n-BuLi intercalation using (c) excess n-BuLi over MoS$_2$ and (d) excess MoS$_2$ over n-BuLi. (e) Thermogravimetric weight loss of the samples in (c, d) showing negligible weight loss in the case of the intercalation with excess MoS2 suggesting lower defect contents. (f, g) Coordination of thiols to vacancy sites from ref. 259. (f) Top: photographs of 1T-MoS$_2$ dispersions after reaction with various ligands, bottom: corresponding zeta potential changes from negative to positive potentials depending on the ligand. (g) IR spectra of the samples showing the disappearance of the S-H vibration (left), but the presence of the rest of the ligand (right). (a,b) Reproduced with permission from ref. 80. Copyright 2015 Nature Publishing Group. (c-e) Reproduced with permission from ref. 260. Copyright 2015 American Chemical Society. (f, g) Reproduced with permission from ref. 259. Copyright 2013 American Chemical Society.
**Fig. 17** MX$_2$ nanoparticle decoration. (a-d) Nanoparticles epitaxially grown on 1T-MoS$_2$. (a-c) TEM images of (a) Pd on 1T-MoS$_2$, (b) Pt on 1T-MoS$_2$, (c) Au on 1T-MoS$_2$. (d) XPS Mo core level spectra showing no changes to the MoS$_2$ on reaction with the metal precursor. (e-g) Au nanoparticles grown on LPE-2H-WS$_2$ from ref. 404. (e) XPS sulfur core level spectra showing evidence for covalent binding of the nanoparticles to the WS$_2$. (f, g) TEM images of Au-decorated LPE-2H-WS$_2$ before (f) and after (g) purification. (a, b) Reproduced with permission from ref. 394. Copyright 2013 Nature Publishing Group. (c, d) Reproduced with permission from ref. 395. Copyright 2013 American Chemical Society. (e-g) Reproduced with permission from ref. 404. Copyright 2018 Nature Publishing Group.
Fig. 18 Tailoring TMDs “beyond MoWSeS” via molecular physisorption. (a) 2H NbSe$_2$ nanosheets are exfoliated via lithium-ion intercalation. Physisorbed hydrazine molecules trigger a structural distortion of the crystal together with novel ferromagnetic properties in superconducting NbSe$_2$. (b) Magnetization vs magnetic field (M–H) curves of hydrazine-treated NbSe$_2$ at 30 K. (c) Temperature-dependent electrical resistivity (R–T curves) of hydrazine-treated NbSe$_2$ under different magnetic fields. (d) Transfer curves of a PdSe$_2$ FET showing a progressive conversion from ambipolar to unipolar $n$-type transport upon thermal annealing. (e) Transfer curves of a PdSe$_2$ FET showing a continuous change from ambipolar to unipolar $p$-type transport via F$_4$-TCNQ physisorption doping. (a–c) Reprinted with permission from ref. 114. Copyright 2016 Nature Publishing Group. (d–e) Reprinted with permission from ref. 113. Copyright 2017 Wiley-VCH.
Fig. 19 Hybrid van der Waals heterostructures. (a) TMDs and other 2D Materials can be superimposed to construct a variety of layered structures with opto electronic properties fundamentally different from those of the isolated sheets. (b-d) AFM images of a highly-ordered molecular monolayers on the surface of MoSe$_2$ (b), MoTe$_2$ (c), WSe$_2$ (d). (e) Schematics of the nanoscale molecular arrangement giving rise to the lamellar assembly observed in panels (b-d). Analogous molecular monolayers could be integrated within inorganic van der Waals heterostructures (a) to obtain hybrid organic/inorganic materials with unique properties. (a) Reprinted with permission from ref. 419. Copyright 2013 Nature Publishing Group. (b-e) Reprinted with permission from ref. 252. Copyright 2016 American Institute of Physics.